



From nano to macro: Introduction to atomistic modeling techniques

Lecture series, CEE, Fall 2005, IAP, Spring 2006

Atomistic modeling of metals and application to the mechanics of ultra thin copper films deposited on substrates

Lecture 2



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Outline and content (Lecture 2)



- Review: Atomistic modeling techniques
- Modeling of metals using pair potentials and multi-body potentials (pair potentials like Morse, LJ, etc., and EAM/MEAM potentials)
- Numerical implementation for modeling the behavior of metals
- Brief review of dislocation mechanics (dislocation interactions, nano-confinement)
- Application: Understanding the mechanical properties of ultra thin copper films deposited on substrates
- Conclusion and outlook



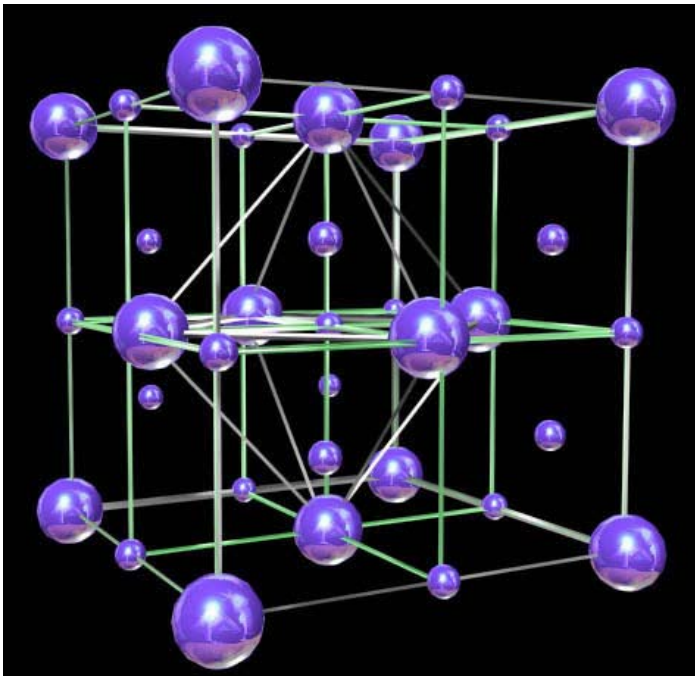
Review: Atomistic modeling techniques



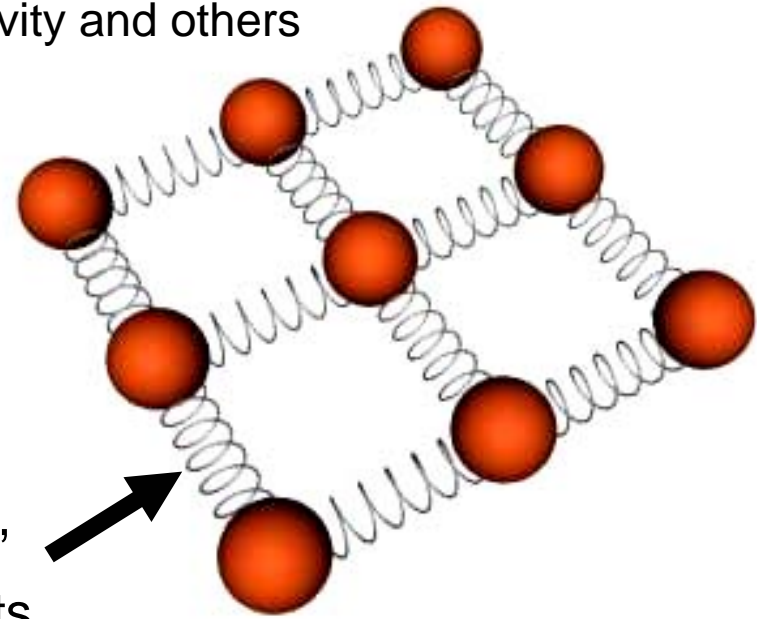
The problem to solve



- In atomistic simulations, the goal is to understand and model the motion of each atom in the material
- The collective behavior of the atoms allows to understand how the material undergoes deformation (metals: dislocations), phase changes or other phenomena, providing links between the atomic scale to meso/macro phenomena



Vibration, change of location, connectivity and others



“Spring”
connects
atoms...

http://www.sr.bham.ac.uk/xmm/images/structures/spherespring_300_248.jpg



Classical molecular dynamics (MD)



- Classical MD calculates the time dependent behavior of a molecular system by integrating their equations of motion (F =force vector, a =acceleration vector)

$$F = ma$$

- The word “classical” means that the core motion of the constituent particles obeys the laws of classical mechanics
- Molecular dynamics simulations generate information at the microscopic level, which are: Atomic positions, velocities, forces
- The conversion of this microscopic information to macroscopic observables such as pressure, stress tensor, strain tensor, energy, heat capacities, etc., requires theories and strategies developed in the realm of statistical mechanics
- Statistical mechanics is fundamental to the study of many different atomistic systems

Important: The Ergodic hypothesis states

$$\langle A \rangle_{ensemble} = \langle A \rangle_{time}$$

Ensemble average = Time average (atomistic data usually not valid instantaneously in time and space)



Integrating the equations of motion



- Verlet algorithm
- Leap-frog algorithm
- Beeman's algorithm

Update of positions

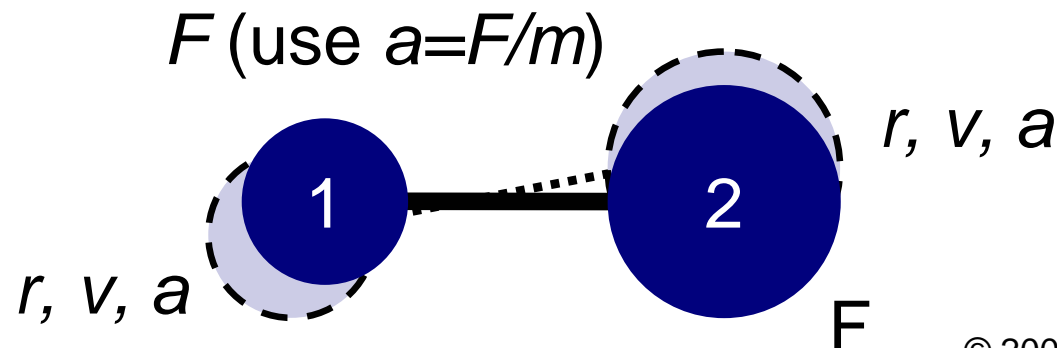
$$r(t + \delta t) = r(t) + v(t)\delta t + \frac{1}{2}a(t)\delta t^2$$

- Velocity Verlet (popular)

Update of velocities

$$v(t + \delta t) = v(t) + \frac{1}{2}[a(t) + a(t + \delta t)]\delta t$$

- Algorithms to control the temperature of a system, pressure, stress, etc. exist (e.g. Nosé-Hoover, Berendsen, etc.)
- NVE, NVT, NPT calculations
- Most calculations in mechanics field are NVE (nonequilibrium phenomena such as fracture)





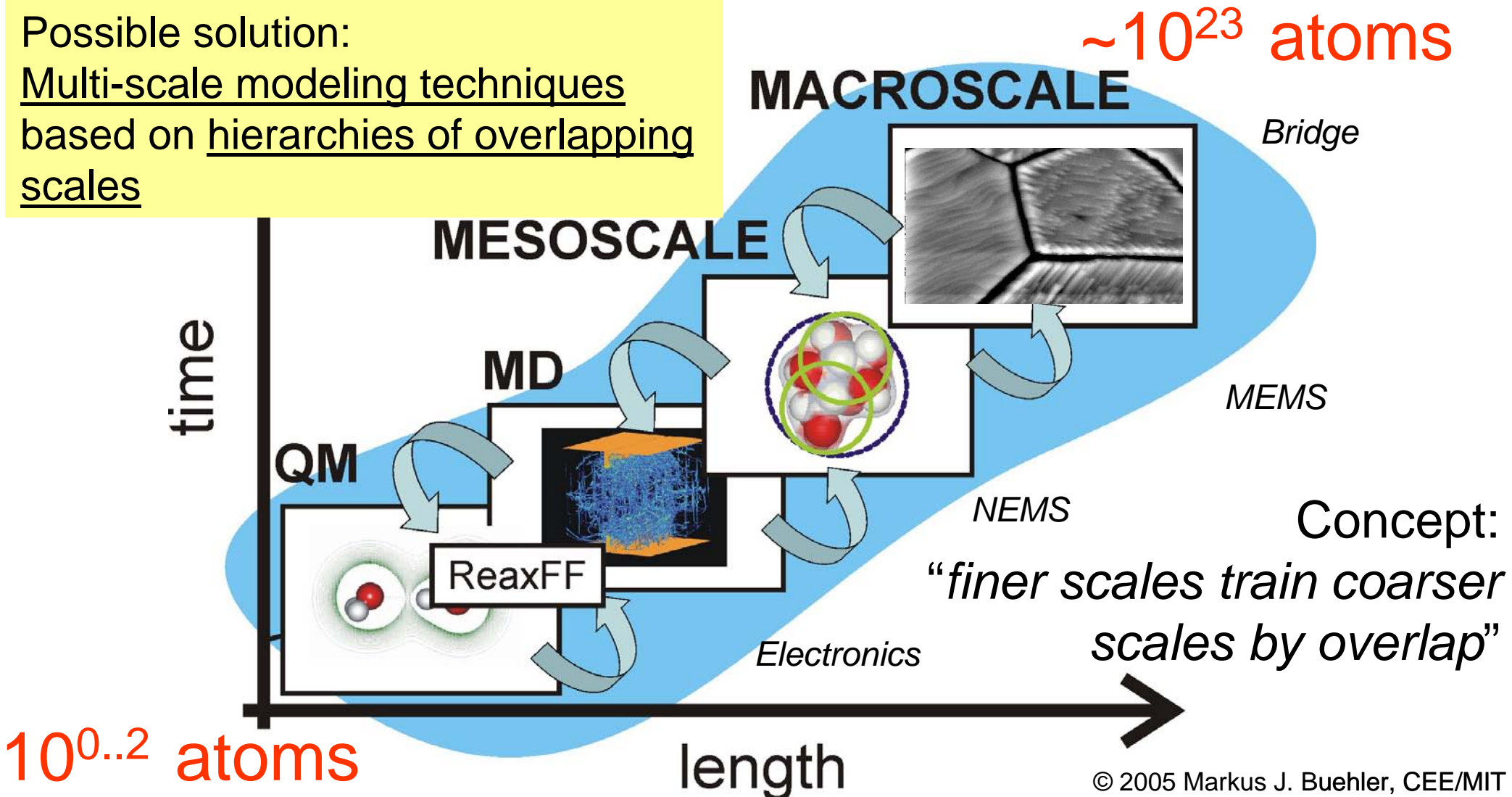
The BIG problem ...



Want: Accuracy of quantum mechanics (QM) in 10^{23} atom systems...

This is impossible (today and in the foreseeable future)

Possible solution:
Multi-scale modeling techniques
based on hierarchies of overlapping
scales





Introduction: Metals and applications



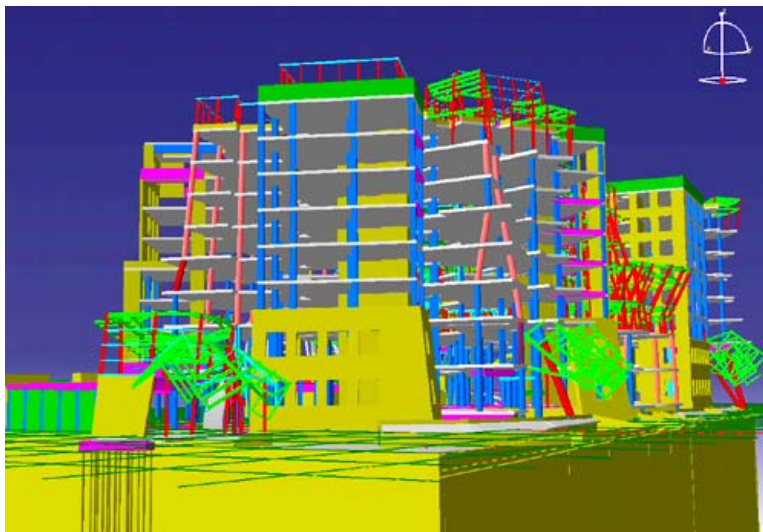
Applications of metals



- Metals are widely used in many applications, ranging from structural mechanics, surfaces, for electronic properties, magnetic properties or for optical devices
- Ages have been named after metals and their alloys (e.g. bronze age, iron age etc.), as their usage has significantly shaped technologies and the world
- Thorough understanding has big impact on engineering, technology and society

Example applications:

- Metals in ultra thin films in semiconductor applications (Cu interconnects)
- Steel frames for high-rise buildings (tensile load)



“large”

web.mit.edu/buildings/statacenter/catia02.htm



“small”

<http://www.mse.berkeley.edu/groups/doyl/e/serdar/RESEARCH/RESEARCH.html>



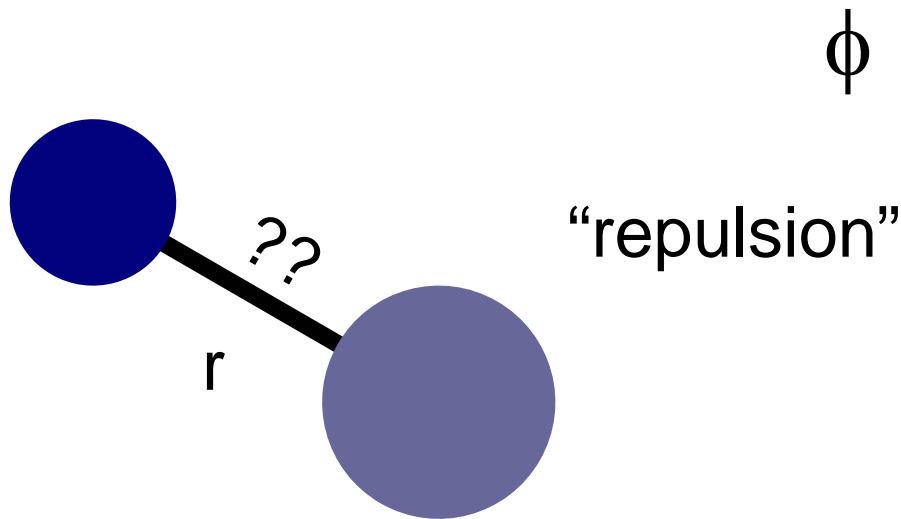
Interatomic potentials for metals



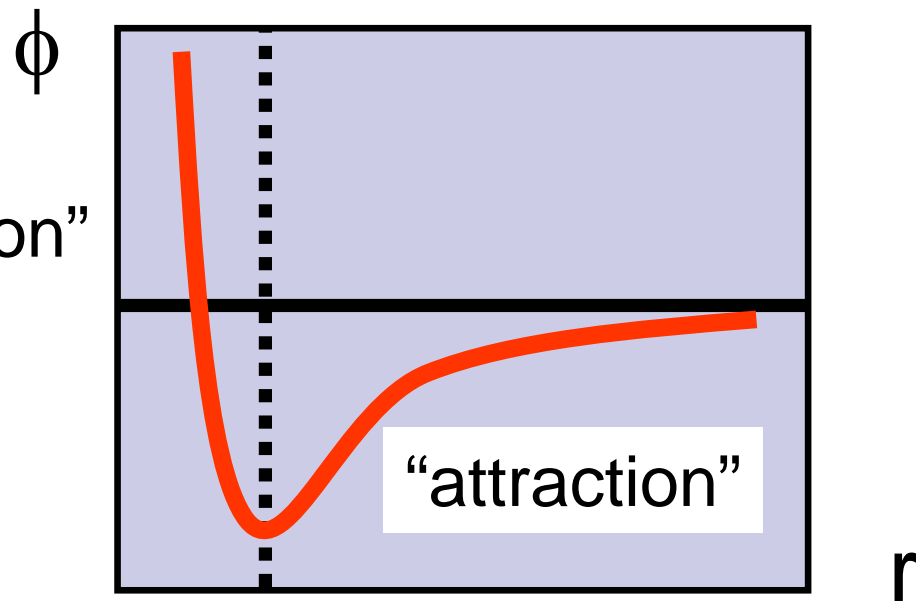
The interatomic potential



- The fundamental input into molecular simulations, in addition to structural information (position of atoms, type of atoms and their velocities/accelerations) is provided by definition of the interaction potential (equiv. terms often used by chemists is “force field”)
- MD is very general due to its formulation, but hard to find a “good” potential (extensive debate still ongoing, choice depends very strongly on the application)
- Popular: Semi-empirical or empirical (fit of carefully chosen mathematical functions to reproduce the potential energy surface...)



Atomic scale (QM) or
chemical property



Forces by $d\phi/dr$



Chemical bonding in metals

“metallic bonding”

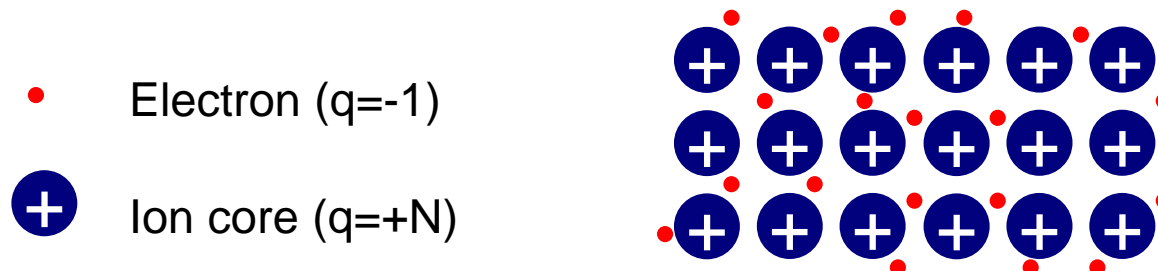


- Bonding between atoms with low electronegativity 1,2 or 3 valence electrons, therefore there are many vacancies in valence shell.
- When electron clouds overlap, electrons can move into electron cloud of adjoining atoms.
- Each atom becomes surrounded by a number of others in a three-dimensional lattice, where valence electrons move freely from one valence shell to another.
- Delocalized valence electrons moving between nuclei generate a binding force to hold the atoms together

positive ions in a sea of electrons

Consequences:

- Electron gas model
- Mostly non-directional bonding, but the bond strength indeed depends on the environment of an atom, precisely the electron density imposed by other atoms





Properties of metals



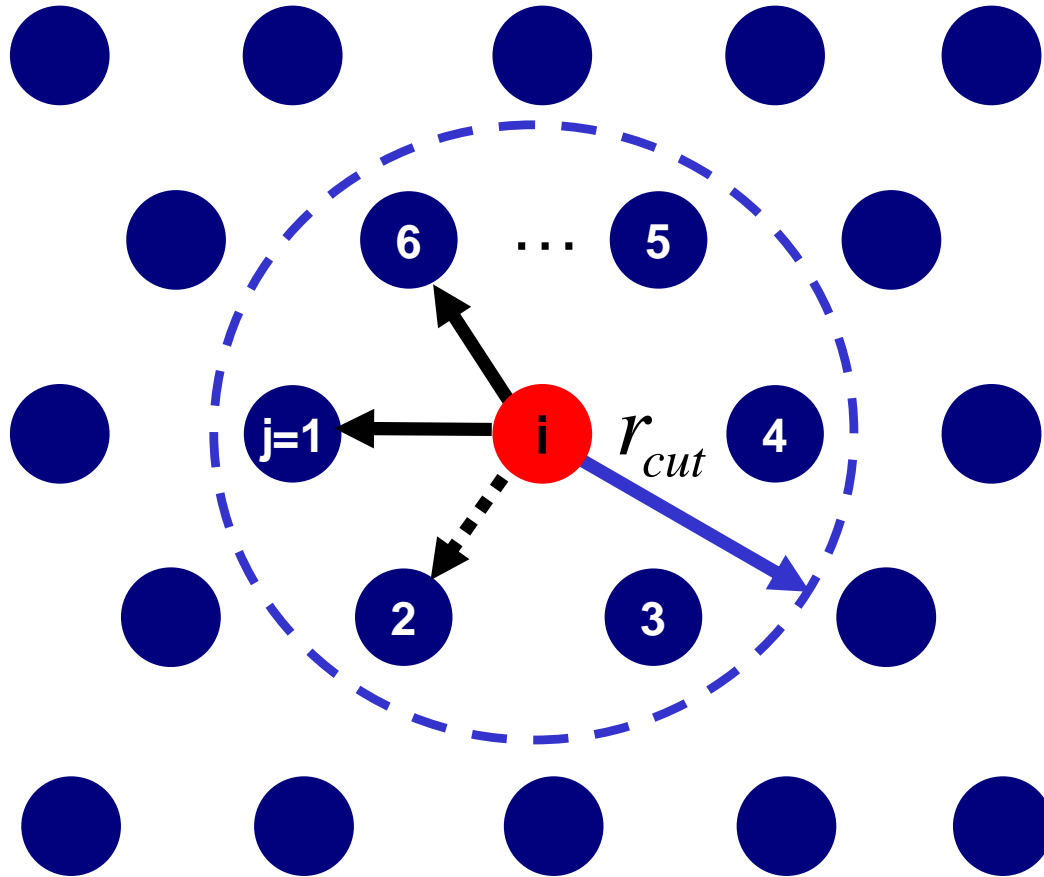
Property	Physical/atomic reason
High density	Tightly packed FCC, BCC, HCP
High melting temperature	Strong forces between ion core and delocalized electrons
Good conductors of heat	Vibration transport via delocalized electrons (+phonons)
Good electrical conductors	Delocalized electrons (flow in and out)
Many metals are ductile	Glide (and climb) of dislocations
Lustrous	Reflection of light by electron gas



Modeling attempts: Pair potential



- First attempts using pair potentials



Good for noble gas Ar
(FCC in 3D)

$$\phi_i = \sum_{j=1..N_{neigh}} \varphi(r_{ij})$$

Lennard-Jones 12:6

$$\varphi(r_{ij}) = 4\varepsilon \left[\left(\frac{\sigma}{r_{ij}} \right)^{12} - \left(\frac{\sigma}{r_{ij}} \right)^6 \right]$$

Morse

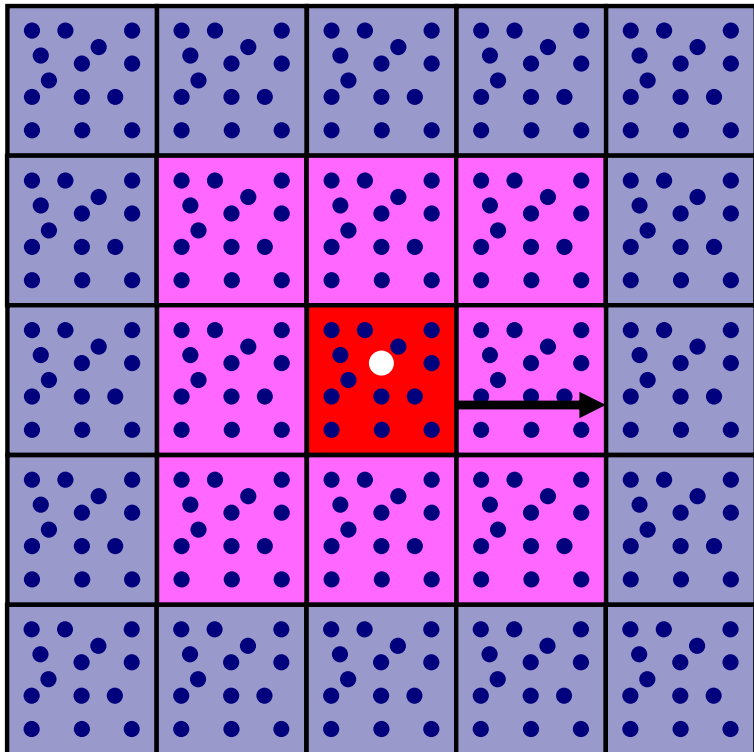
$$\varphi(r_{ij}) = D \{ 1 - \exp[-\beta(r_{ij} - r_0)] \}^2$$



Numerical implementation of neighbor search: Reduction of N^2 problem to N problem



- Need nested loop to search for neighbors of atom i : Computational disaster
- Concept: Divide into computational cells (“bins”, “containers”, etc.)
- Cell radius $R > R_{\text{cut}}$ (cutoff)



- Search for neighbors within cell atom belongs to and neighboring cells (8+1 in 2D)
- Most classical MD potentials/force fields have finite range interactions
- Other approaches: Neighbor lists
- Bin re-distribution only necessary every 20..30 integration steps (parameter)



Why pair potentials fail...



- In pair potentials, the strength of each bond is dependent only on the distance between the two atoms involved:

The positions of all the other atoms are not relevant
(works well e.g. for Ar where no electrons are available for bonding and atoms are attracted with each other only through the weak van der Waals forces)

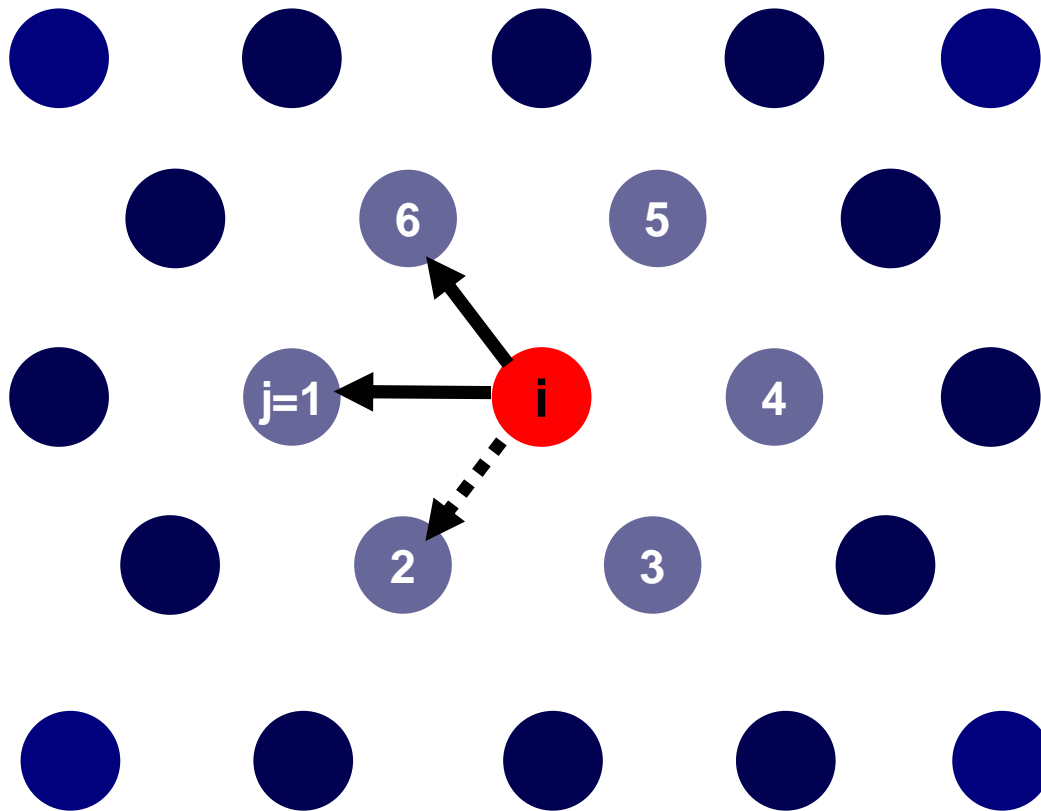
- However: QM tells that the strength of the bond between two atoms **is affected by the environment** (other atoms in the proximity)
- As a site becomes more crowded, the bond strength will generally decrease as a result of Pauli repulsion between electrons. The modeling of many important physical and chemical properties depends crucially on the ability of the potential to "adapt to the environment"
- Consequences:
 - Can not reproduce surface relaxation
 - Cauchy relation

$$c_{12} / c_{44} = 1 \quad \text{Not satisfied in most metals (e.g. Au } c_{12} / c_{44} = 3.7)$$



Modeling attempts: Multi-body potential

- Multi-body potential depend on more than pairs of atoms, but instead also on the environment of each atom
- Important for metals due to the “electron gas”



$$\phi_i = \underbrace{\sum_{j=1..N_{neigh}} \frac{1}{2} \varphi(r_{ij})}_{\text{Pair potential energy}} + \underbrace{F(\rho_i)}_{\text{Embedding energy as a function of electron density}}$$

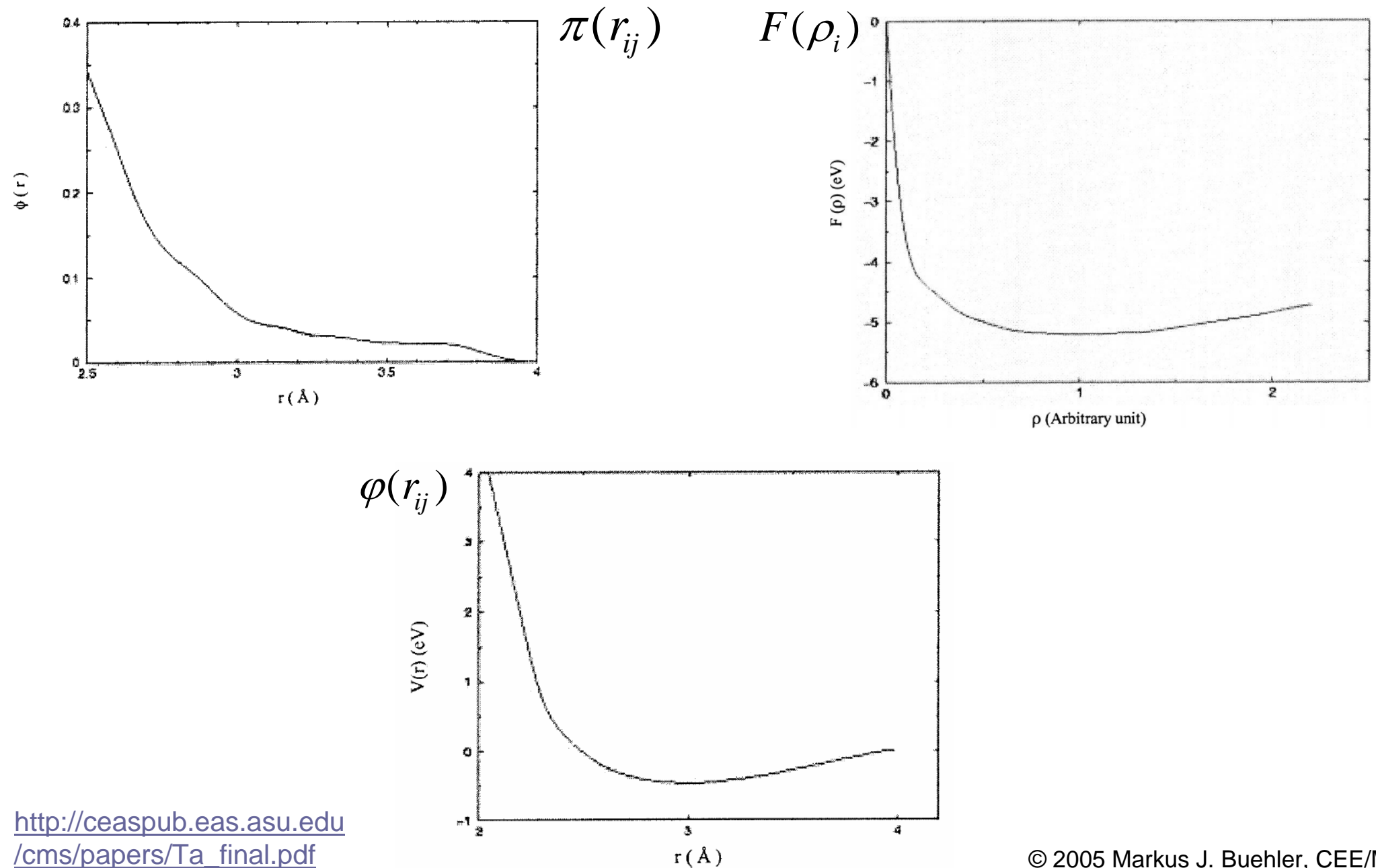
new

ρ_i Electron density at atom i based on a pair potential:

$$\rho_i = \sum_{j=1..N_{neigh}} \pi(r_{ij})$$



Example: EAM potential for Ta

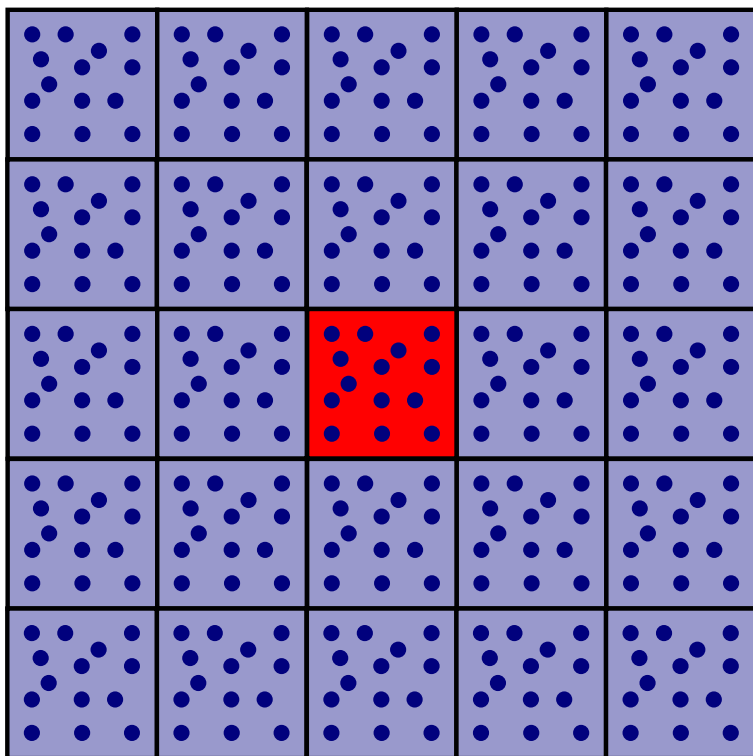




Numerical implementation of multi-body EAM potential



- Requires two loops over atoms within each cell



Loop 1:

(i) Pair contributions (derivatives and potential)

(ii) Calculate electron density

Loop 2:

(iii) Calculate embedding function and derivatives

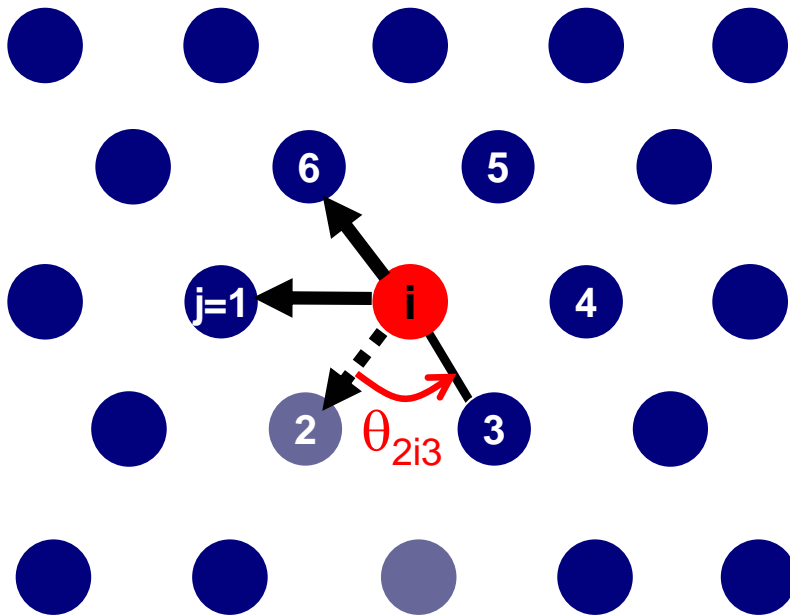
$$\mathbf{F}_i = - \sum_{j \neq i} \left(\phi'(r_{ij}) + [U'(n_i) + U'(n_j)] \rho'(r_{ij}) \right) \frac{\mathbf{r}_{ij}}{r_{ij}}$$

Due to additional (i) calculation of electron density and (ii) embedding contribution EAM potentials are 2-3 times slower than pure pair potentials



Modeling attempts: MEAM method

- MEAM potentials introduce an additional angular term to account for covalent, directional character of bonding, which is critical in some metals (e.g. Ta due to partially filled d-orbitals) and semiconductors (e.g. Si)




$$\rho_i = \frac{2\rho_i^{(0)}}{1 + \exp \left[- \sum_{s=1}^3 t_i^{(s)} \left(\rho_i^{(s)} / \rho_i^{(0)} \right)^2 \right]}$$

$$\phi_i = \underbrace{\sum_{j=1..N_{neigh}} \frac{1}{2} \varphi(r_{ij})}_{\text{Pair potential energy}} + \underbrace{F(\rho_i)}_{\substack{\text{Embedding energy} \\ \text{as a function of} \\ \text{electron density}}}$$

ρ_i Electron density at atom i contains three-body contributions:

$$\left(\rho_i^{(s)} \right)^2 = \sum_{j,k \neq i} \rho_j^{a(s)}(r_{ij}) \rho_k^{a(s)}(r_{ik}) L^{(s)}(\cos \theta_{jik})$$

Loop over triple pairs

 angular term



Derivation or “training” of potentials



- Training of parameters is done so that experimental or quantum mechanical results are reproduced
- The success of training depends on the choice of the potential form (analytical) and its ansatz (e.g. include knowledge from QM about chemical bonding (realized in EAM potentials))

Implementations

- Parameter fitting through a (i) training set of data (pairing desired values and structural information including relative weights to define a cost function) and a (ii) potential formulation with variable parameters
 - Force Matching Method (systematic approach to fit potential to a large database of force data from DFT)
 - Genetic algorithm or other optimization schemes
 - By hand or intuition (less effective)

Notes

- Whole research groups dedicated to the problem of potential derivation
- Means to transport information across the scales (see Lecture 1)



The force matching method



- Developed 1992,1993 at UIUC
- Basic idea: Obtain realistic classical empirical potentials by making use of very large amounts of information obtained by first-principles calculations (EOS, lattice constant, cohesive energy, elastic properties..)
- E.g., as mathematical form use cubic splines to define the potential shape
- Many flavors and similar approaches have been developed in recent years

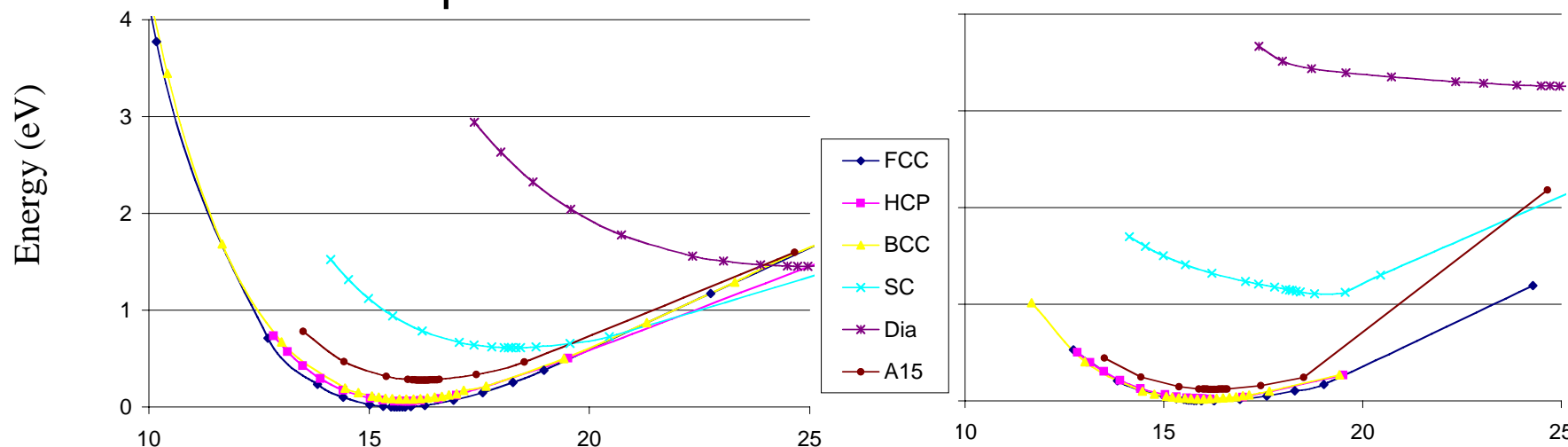
- Examples for application of force matching method:
 - *Alumuinum, Europhys. Lett. 26, 583 (1994)*
 - *Magnesium, Modelling and simulation in materials science and engineering 4, 293 (1996), by X.-Y. Liu et al.*



Example: Equation of state for metals

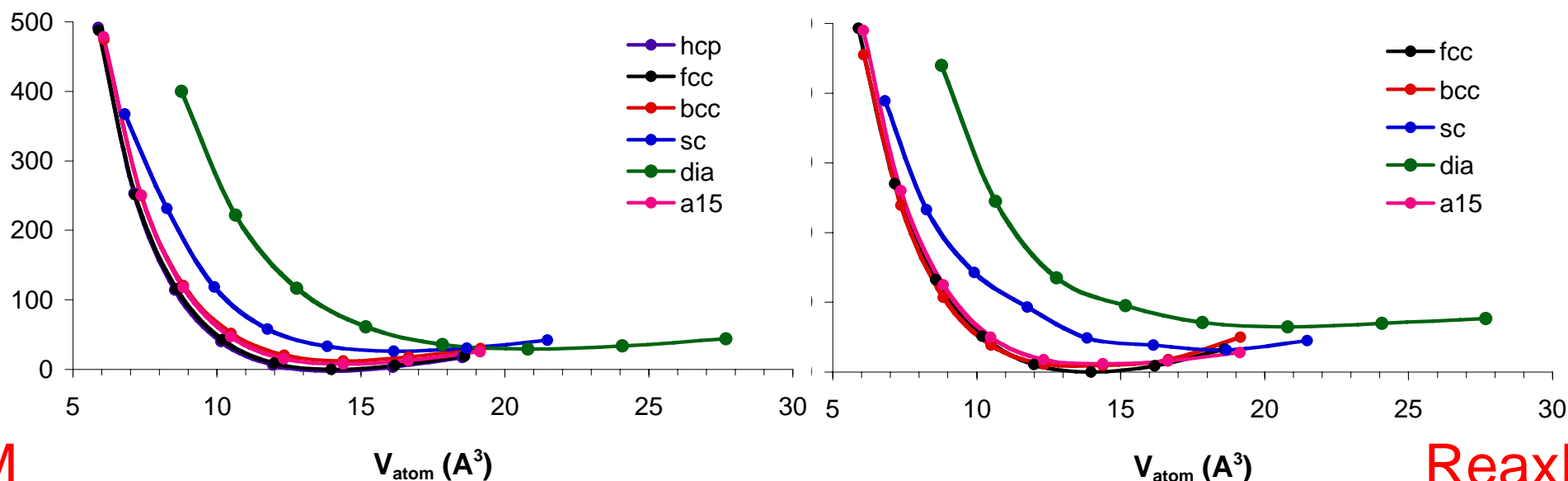


Platinum metal bulk phases



Ruthenium metal bulk phases

(van Duin et al.)



QM

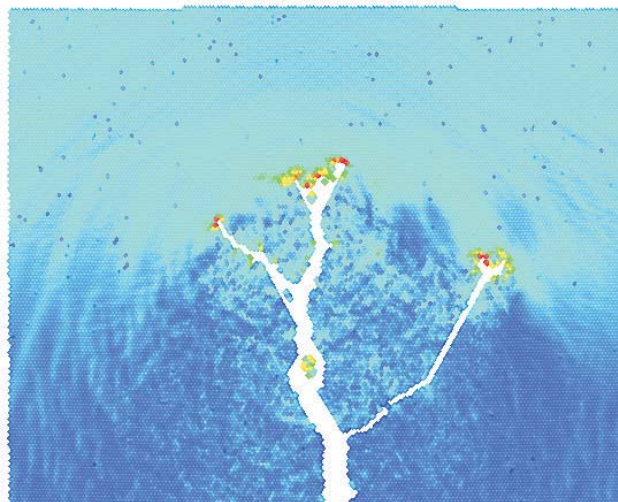
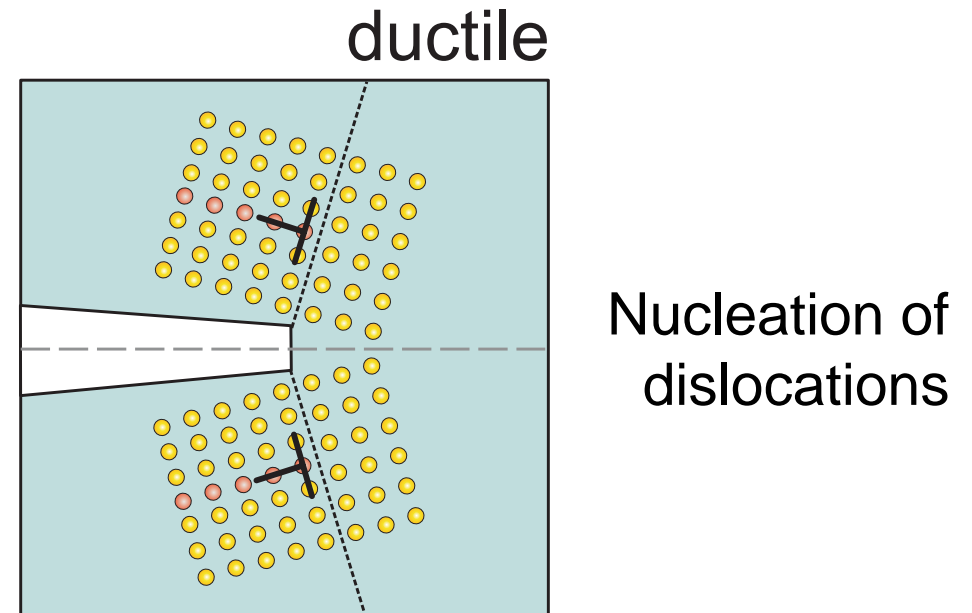
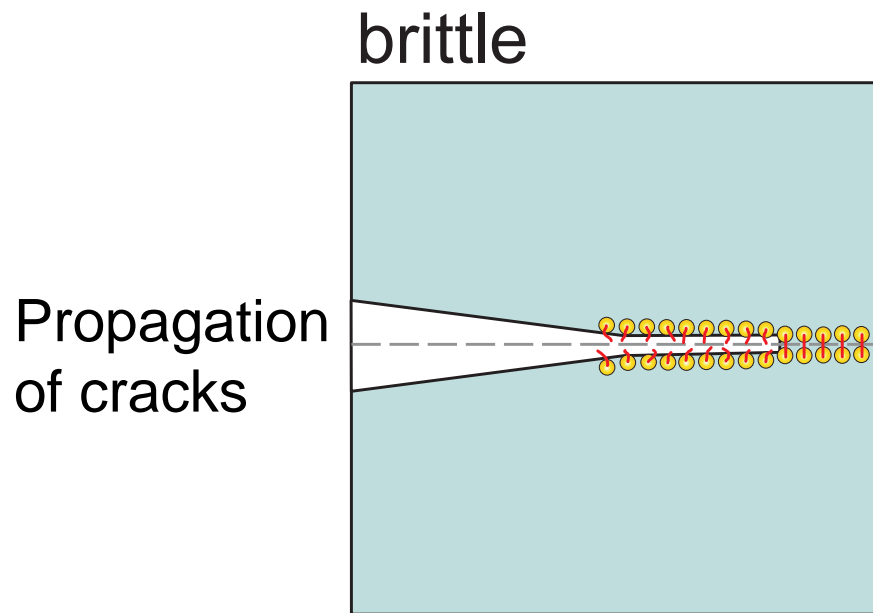
ReaxFF



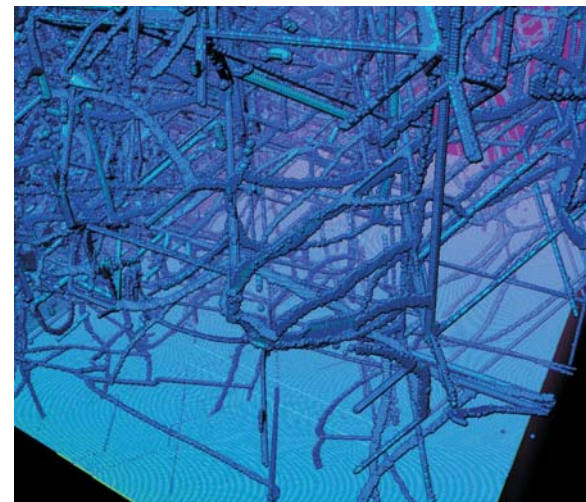
Theoretical concepts and experimental results



Ductile versus brittle materials



(a)



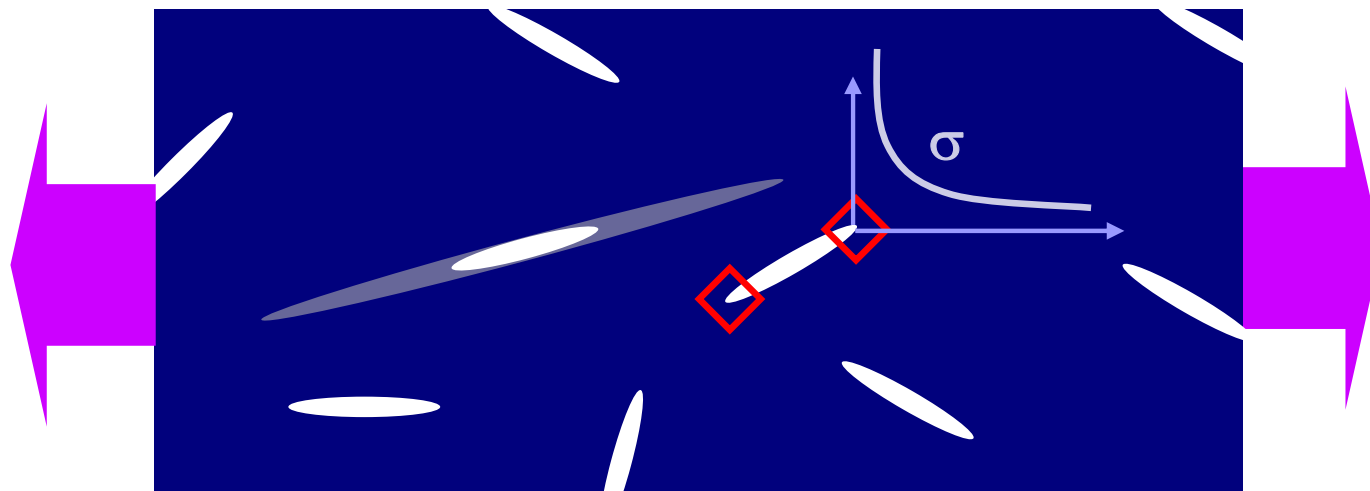
(b)

(Buehler, 2004)

Cracks govern the strength of materials



- The strength of materials is dominated by the existence of cracks or other defects (“flaws”)
- Cracks and similar defects lead to stress concentrations, which in turn lead to nucleation of dislocations or generation of new material surfaces
- Cracks and defects explain the reduced theoretical strength of materials (up to 1,000 compared to theoretical prediction)



Griffith



Review on fracture mechanics: Cracks matter



- To analyze the relationship among stresses, cracks, and fracture toughness, **Fracture Mechanics** was introduced. The first milestone was set by Griffith in his famous 1920 paper that quantitatively relates the flaw size to the fracture stresses.
Griffith's approach is only suitable for **brittle materials**.

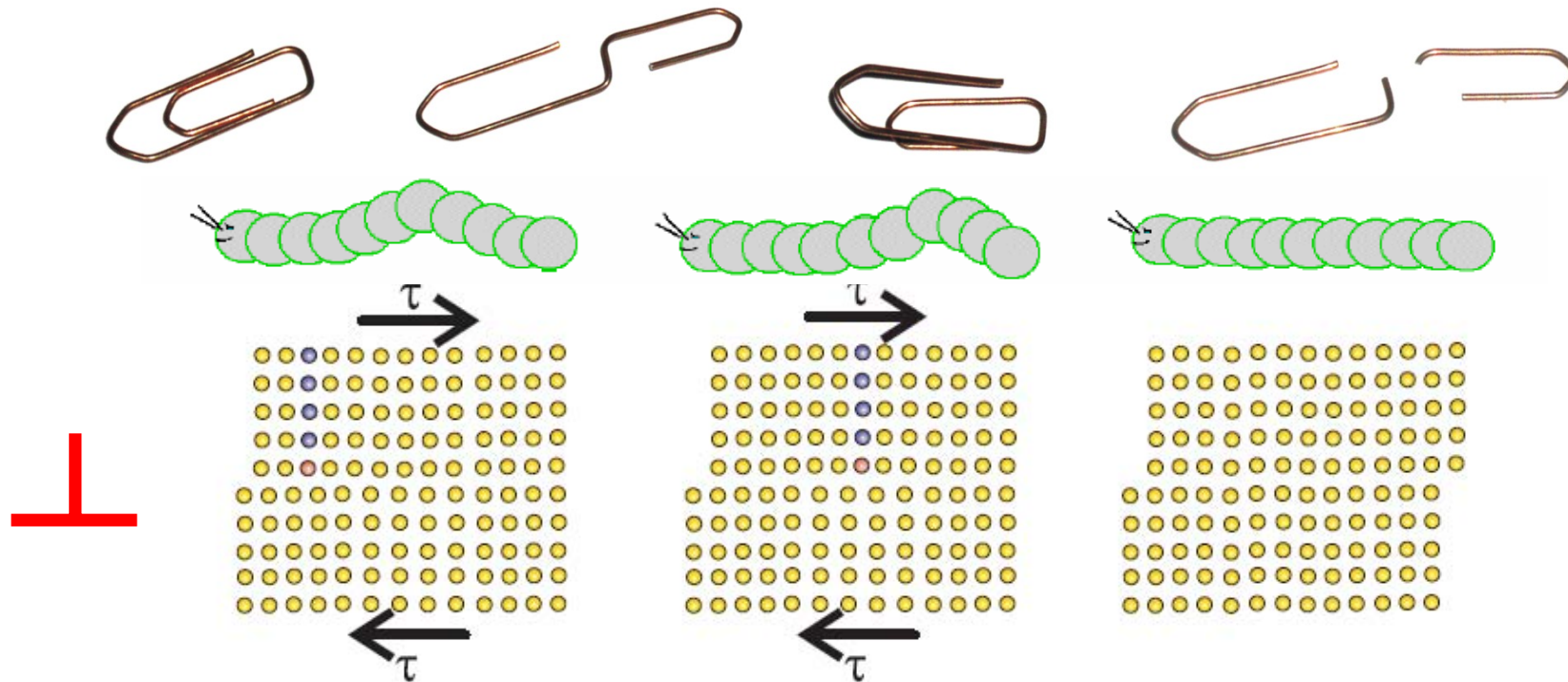
$$\sigma_c = \left(\frac{2E\gamma_s}{\pi a} \right)^{1/2}$$

- For **ductile materials**, the milestone did not come about until Irwin developed the concept of **strain energy release rate**, G , in 1950s. G is defined as the rate of change in potential energy near the crack area for a linear elastic material.
- When the **strain energy release rate** reaches the critical value, G_{cr} , the crack will grow. Later, the strain energy release rate G was replaced by the **stress intensity factor** K with a similar approach by other researchers.

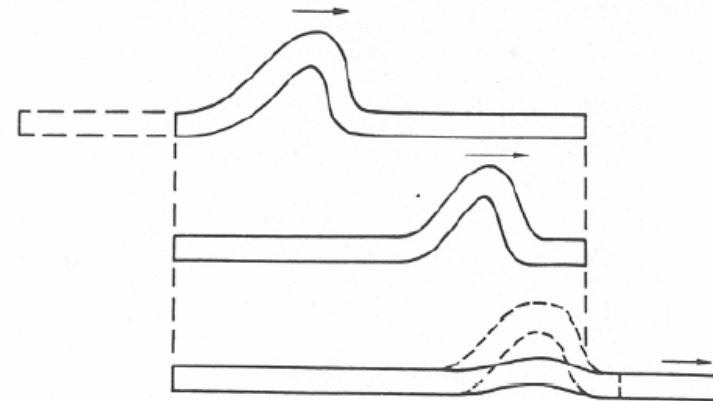
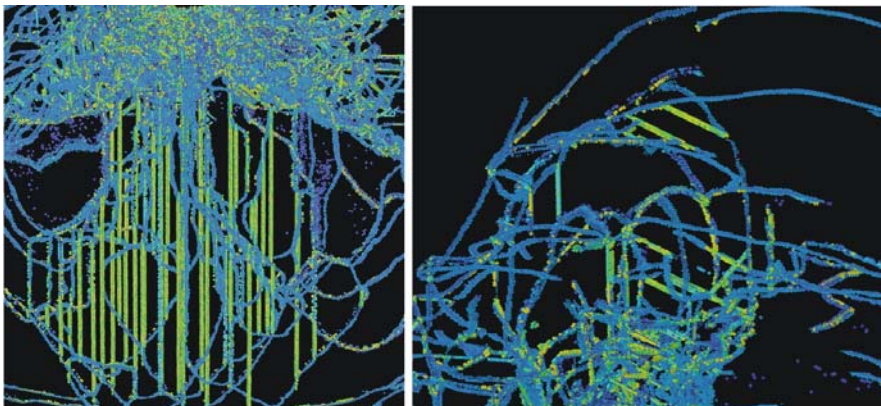
$$G = 2(\gamma_s + \gamma_p) \quad G = G_I + G_{II} + G_{III} = \frac{1-\nu^2}{E} \left(K_I^2 + K_{II}^2 + \frac{K_{III}^2}{1-\nu} \right)$$



Ductile materials are governed by the motion of dislocations: Introduction



Dislocations are the entities that carry plastic (permanent) deformation

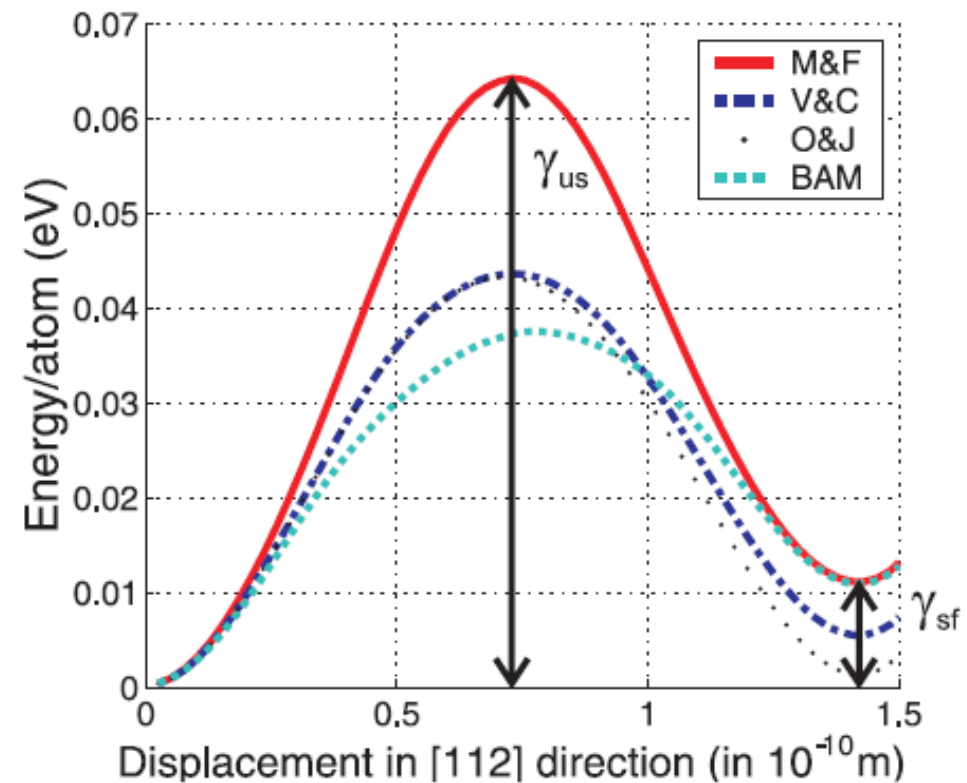
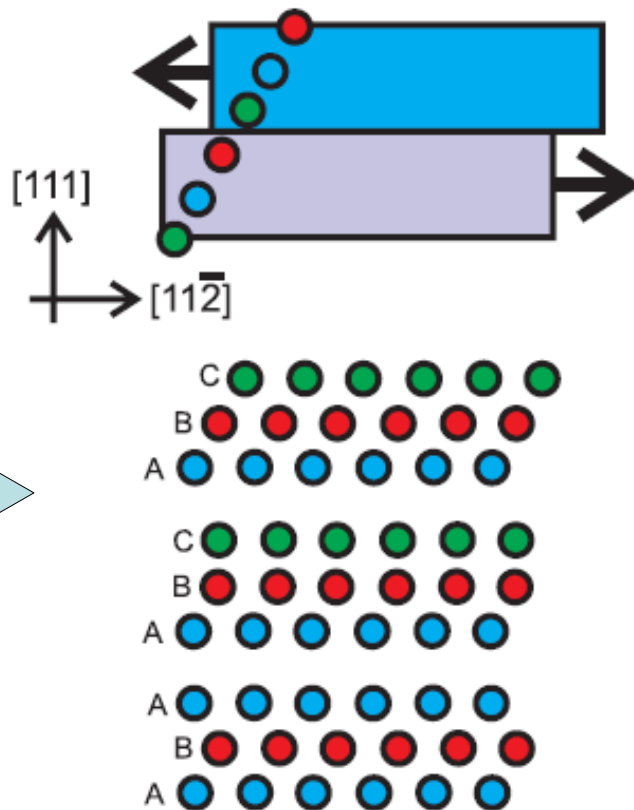




Stacking fault energy



Difficulty of creating a dislocation and moving a dislocation through the crystal

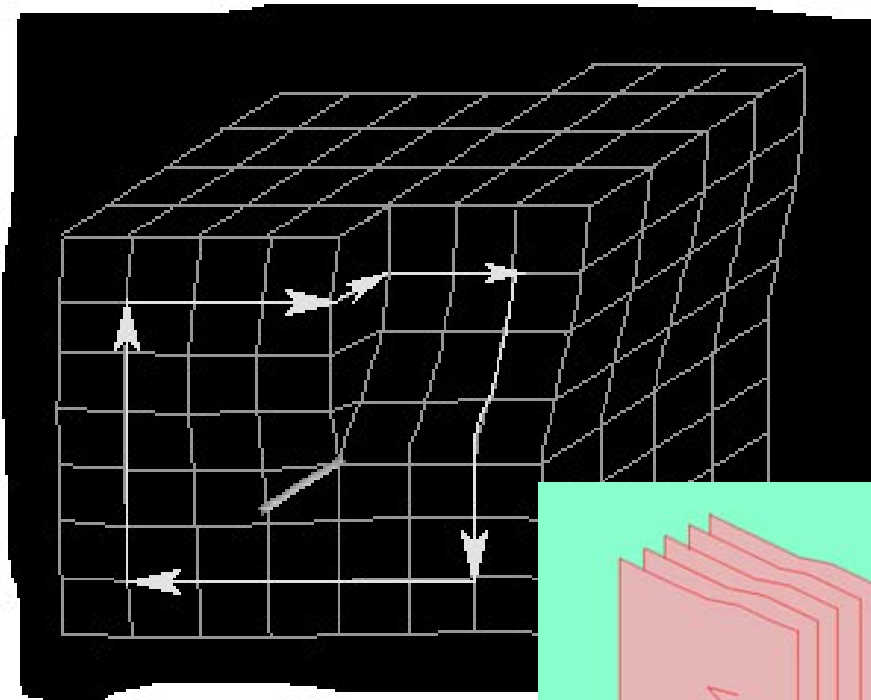


(Buehler, 2006)

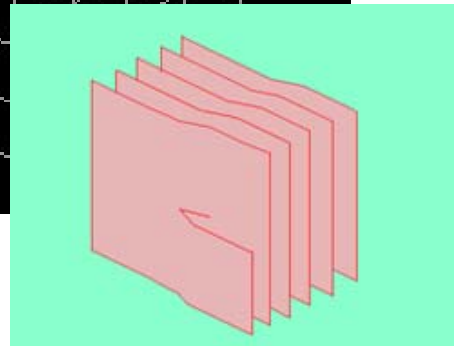
Calculation of stacking fault energy for different interatomic potentials



Edge and screw dislocations



Screw dislocation

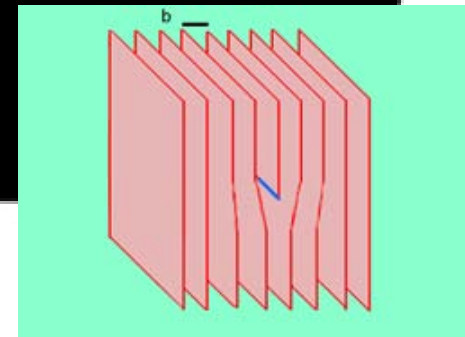
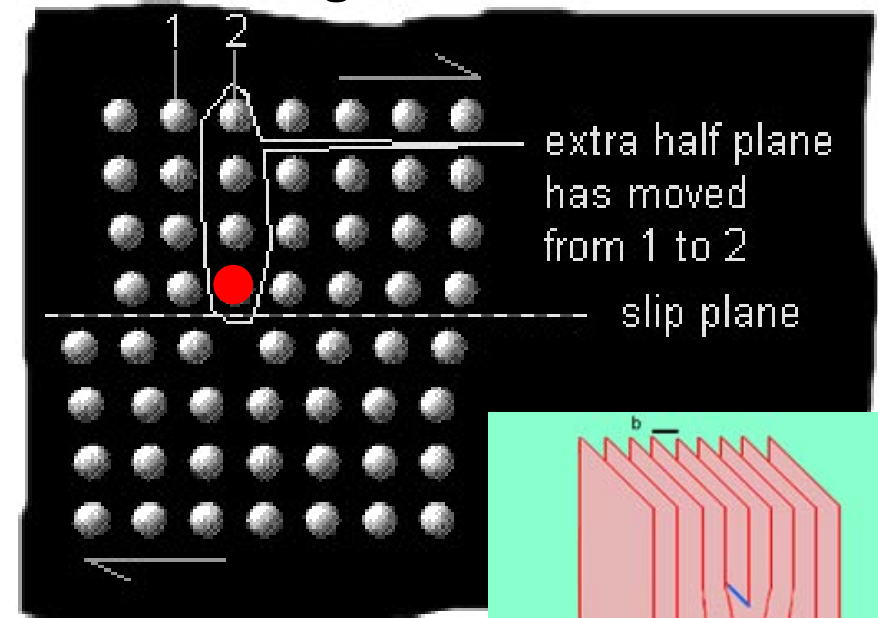


Dislocation line

Burgers vector

Screw, edge dislocations

Edge dislocation

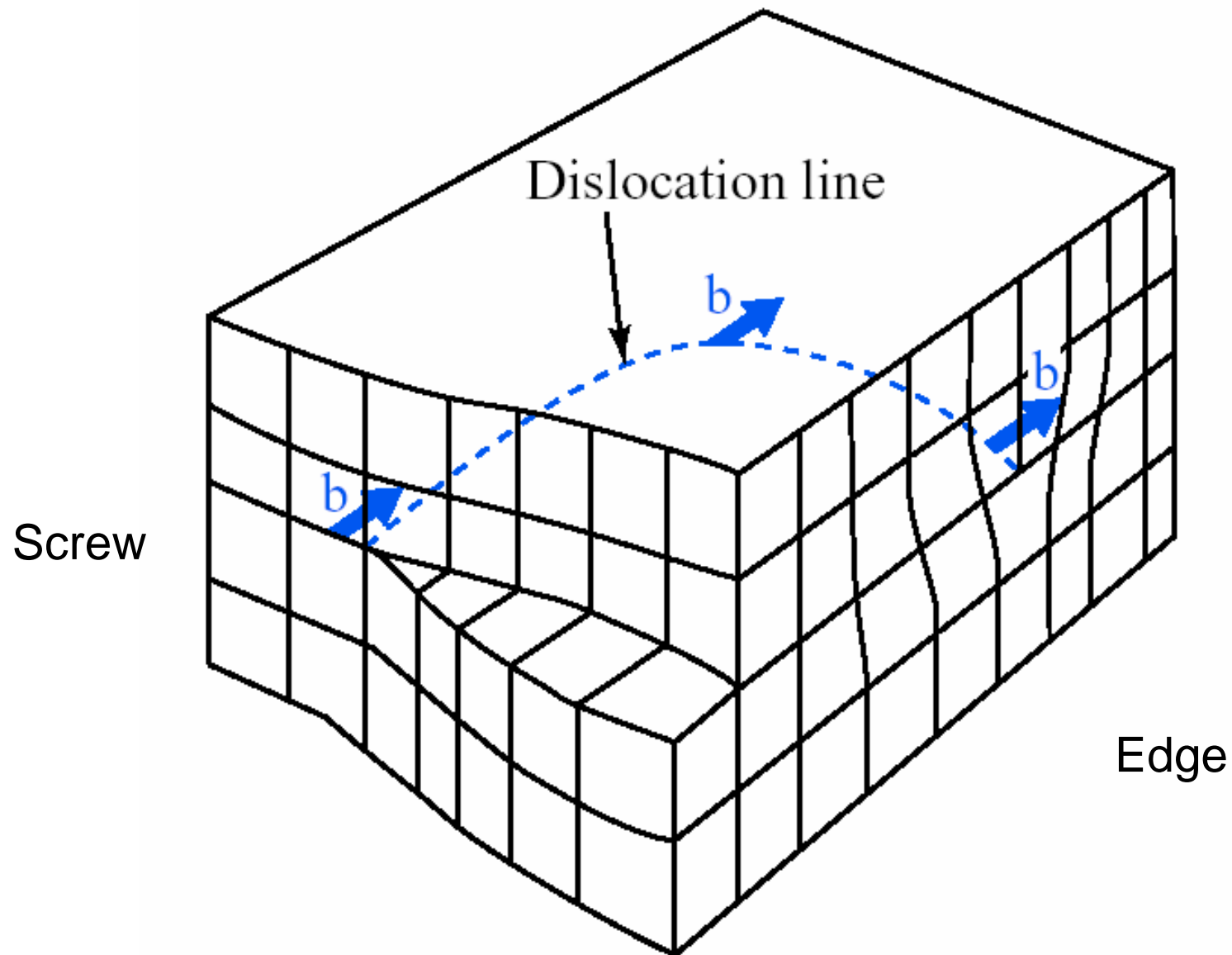


Other crystal defects

Grain boundaries,
vacancies, interstitials



Screw versus edge dislocation

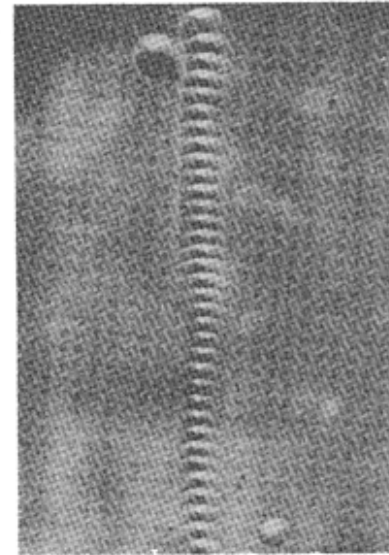




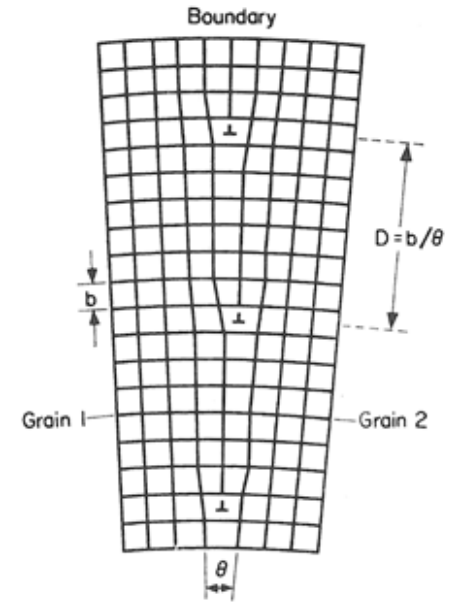
Experimental observation



Transmission Electron
Micrograph of
dislocations (TEM)



(a)



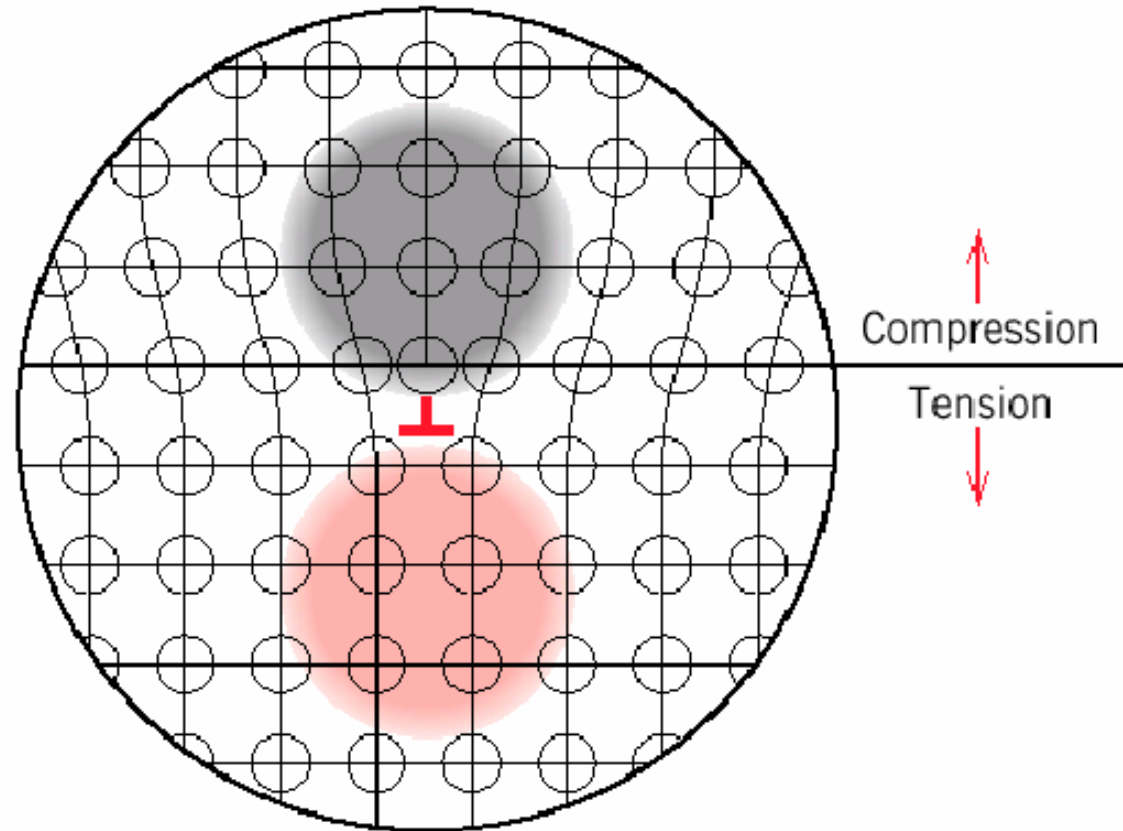
(b)

GB misfit dislocations

Dieter, G. E. (1988) *Mechanical Metallurgy* ISBN 0071004068
Honeycombe, R.W.K. (1984) *The Plastic Deformation of Metals* ISBN 0713121815
Hull, D. & Bacon, D. J. (1984) *Introduction to Dislocations* ISBN 0080287204
Read, W. T. Jr. (1953) *Dislocations in Crystals* ISBN 1114490660



Dislocations: Stress field around a dislocation



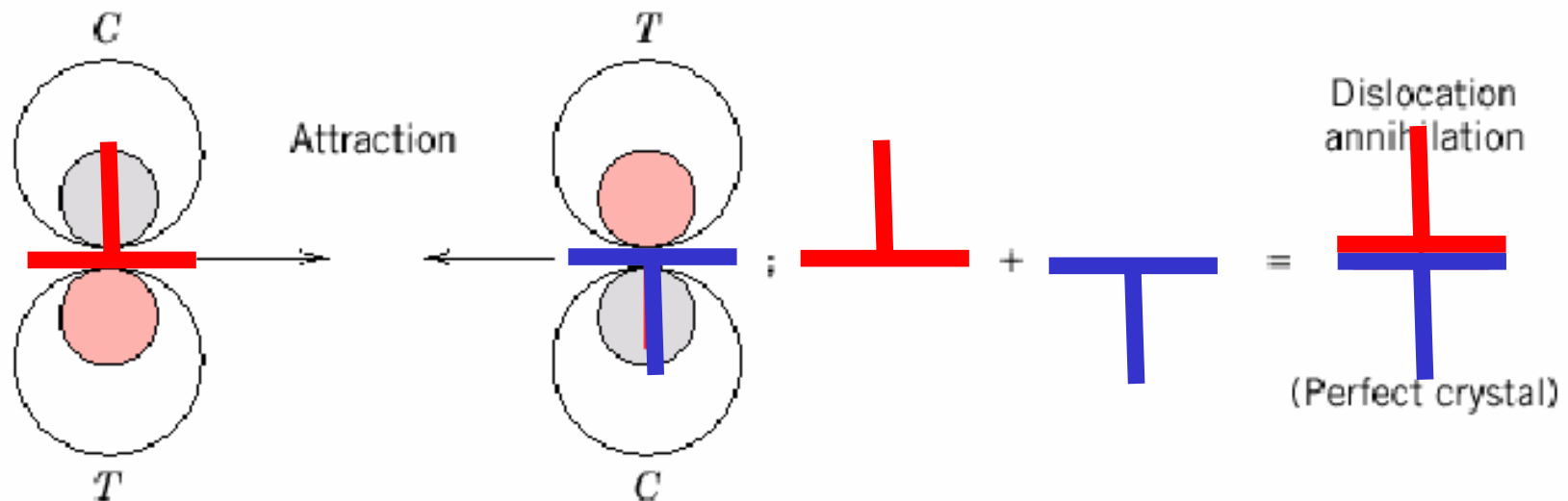
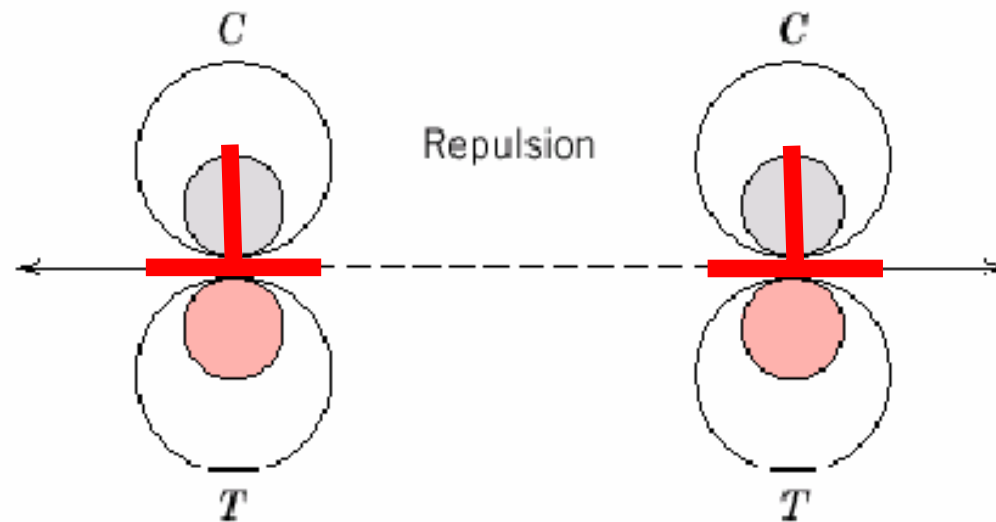
Dislocations lead to a tensile-compressive stress field in their vicinity



Dislocations: Interaction



Important to understand how materials deform





Motion of dislocations



$$\vec{F}_d = (\sigma \cdot \vec{b}) \times \vec{\xi}$$

Peach-Koehler force: Drives dislocation motion

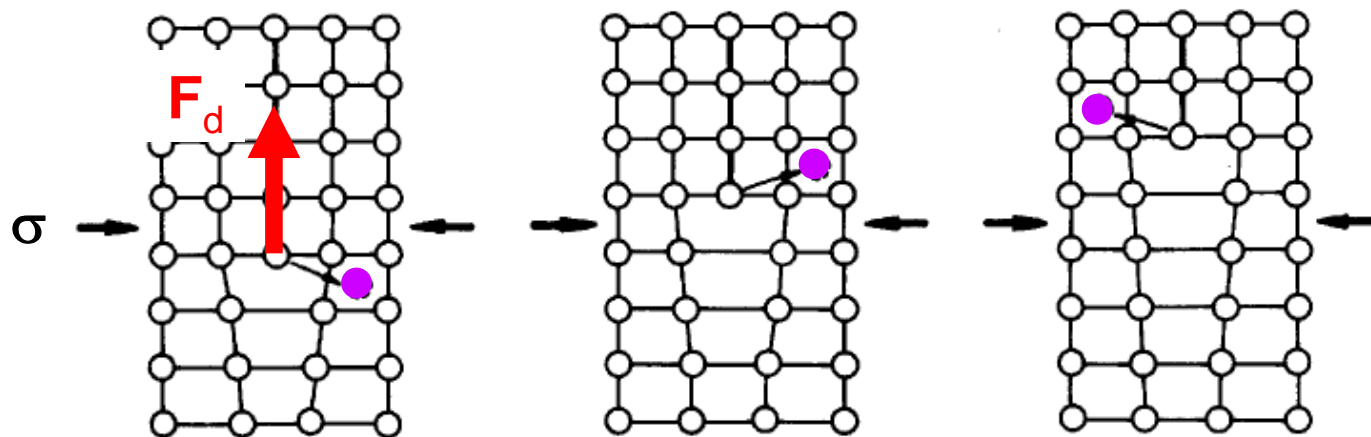
σ Applied stress

Resolved shear stress on dislocation

\vec{b} Burgers vector

$\vec{\xi}$ Line direction

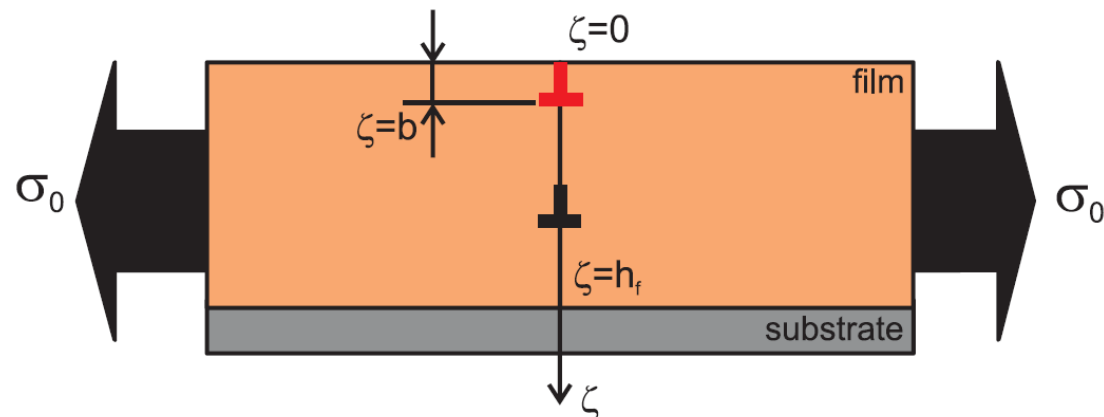
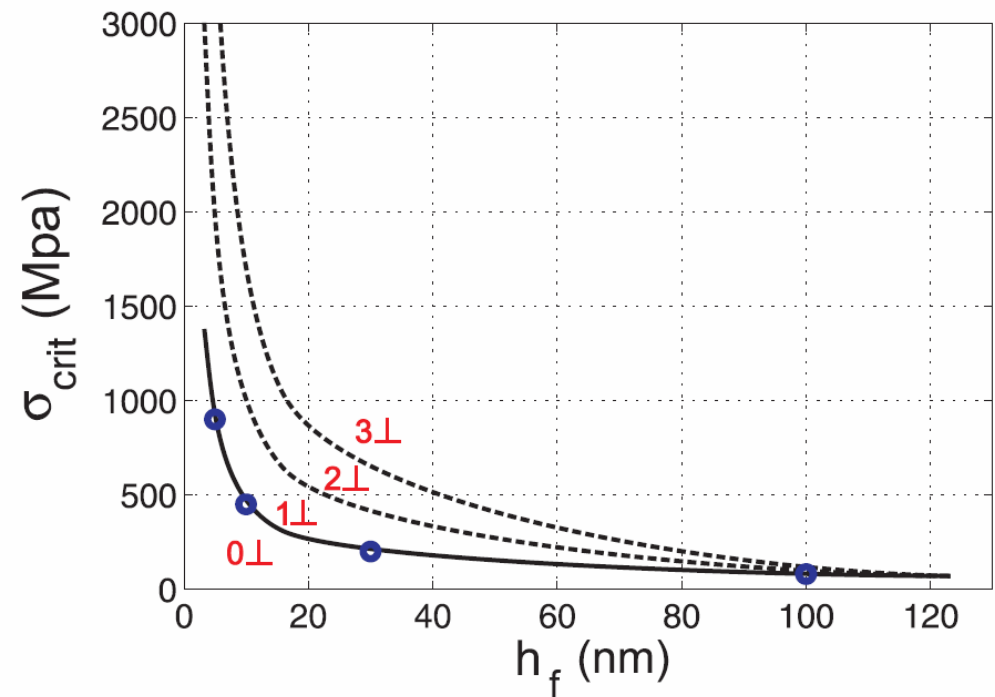
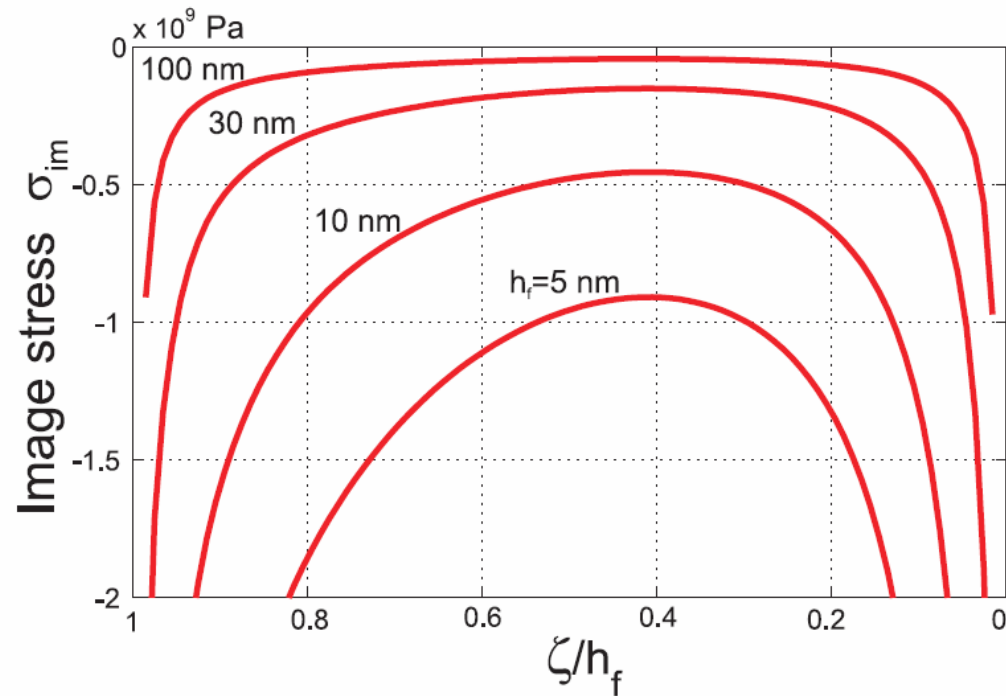
“Climb of dislocations” (nonconservative)



Emission of interstitials during climb



Nano-confinement of dislocations in ultra thin films on substrates

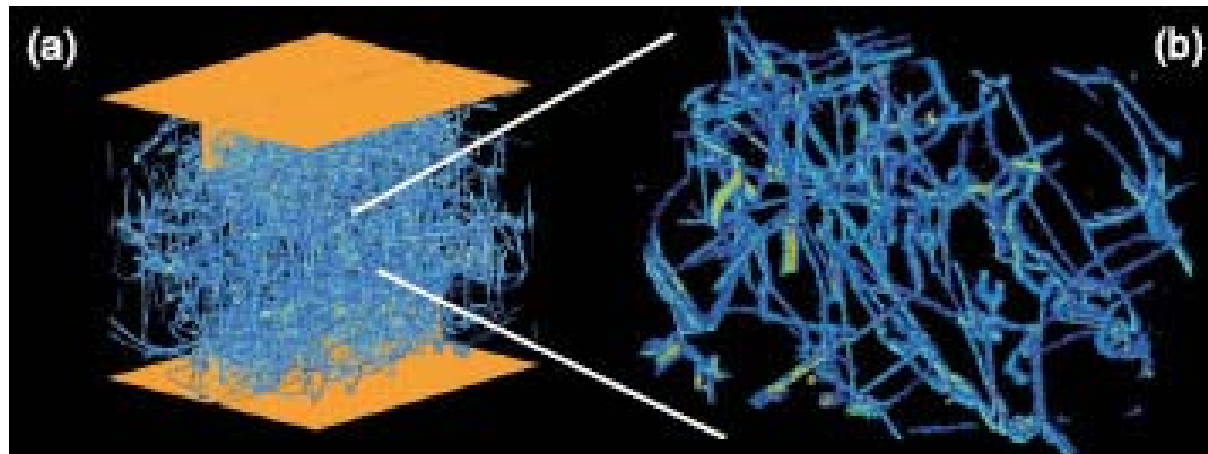


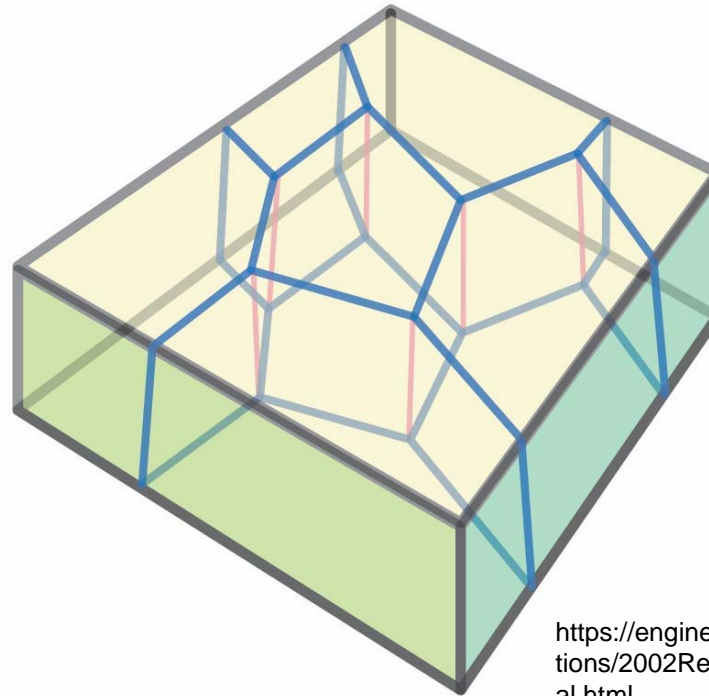


Summary: The nature of dislocations



- Dislocations are complex line defects with complicated interaction with each other and other defects and the crystal lattice
- They are made up out of atoms, but all atoms are not necessary to describe their behavior unless they undergo reactions; long-range interactions
- Dislocations are critical to understand the behavior of many materials, in particular metals
- Modeling of atomistic dislocations with realistic material dimensions of micrometers and beyond has so far been elusive
- Current research efforts e.g. at SNL/LANL are geared towards developing models that describe deformation of materials based on fundamental principles
- Dislocations also appear in molecular crystals; but their role remains unclear



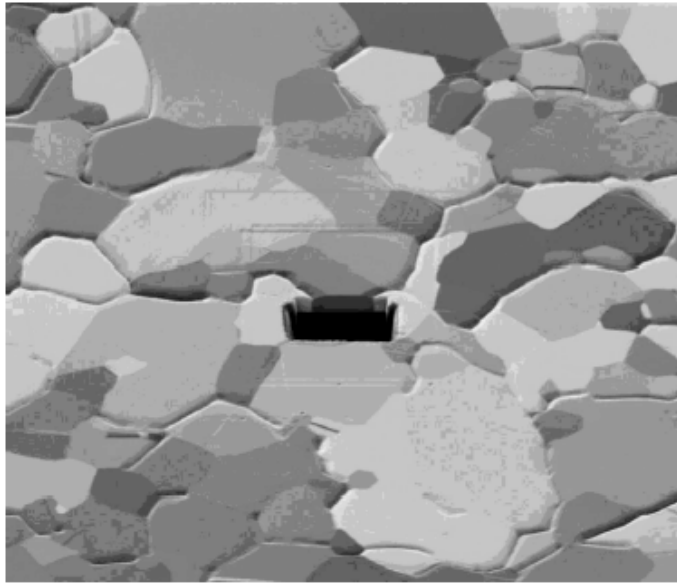


https://engineering.purdue.edu/Engr/Research/Publications/2002ResearchReport/nanotech_spotlight_material.html

Mechanics of ultra thin copper films

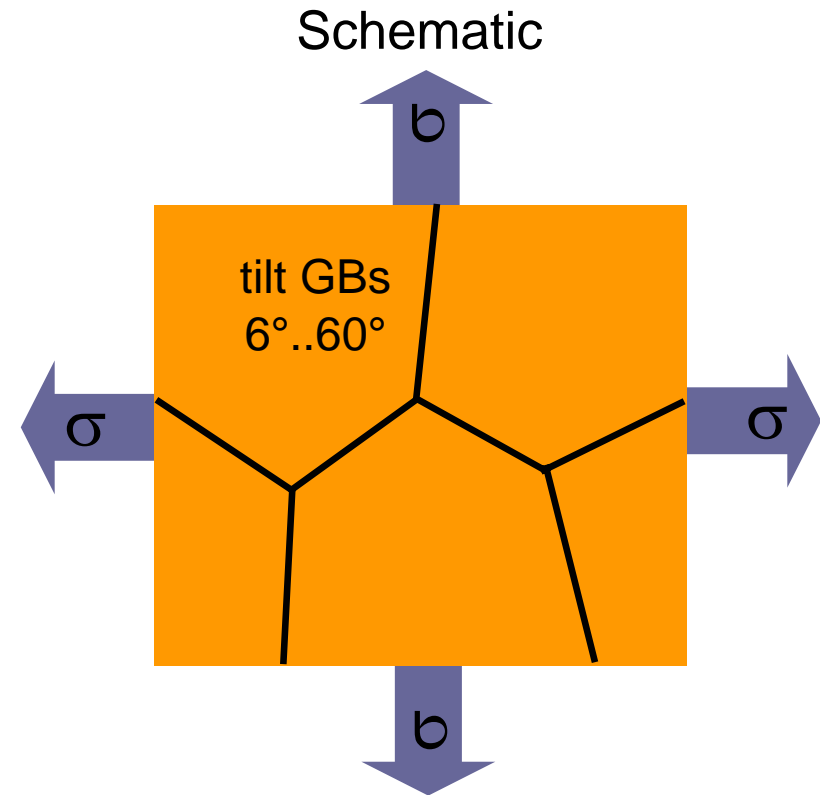


Introduction



Courtesy Dirk Weiss, MIT

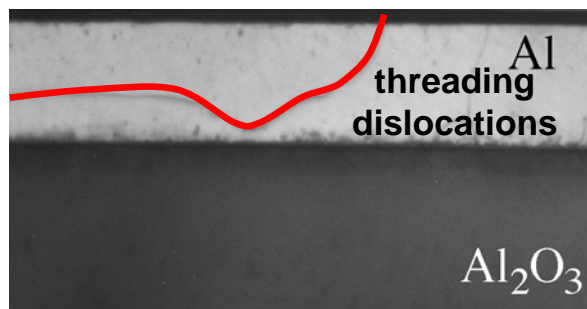
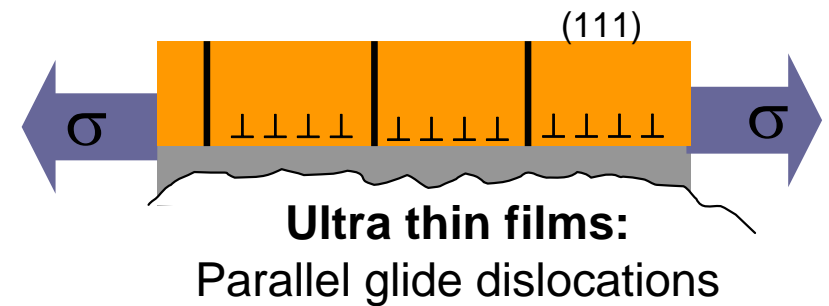
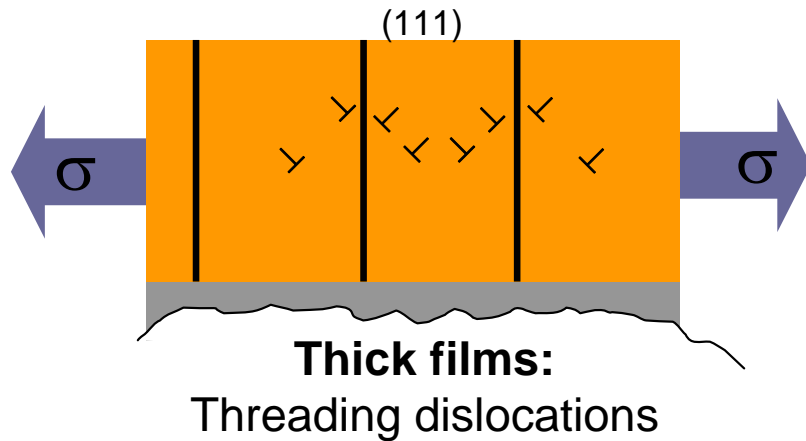
Polycrystalline thin metal film of copper
grains (111) aligned



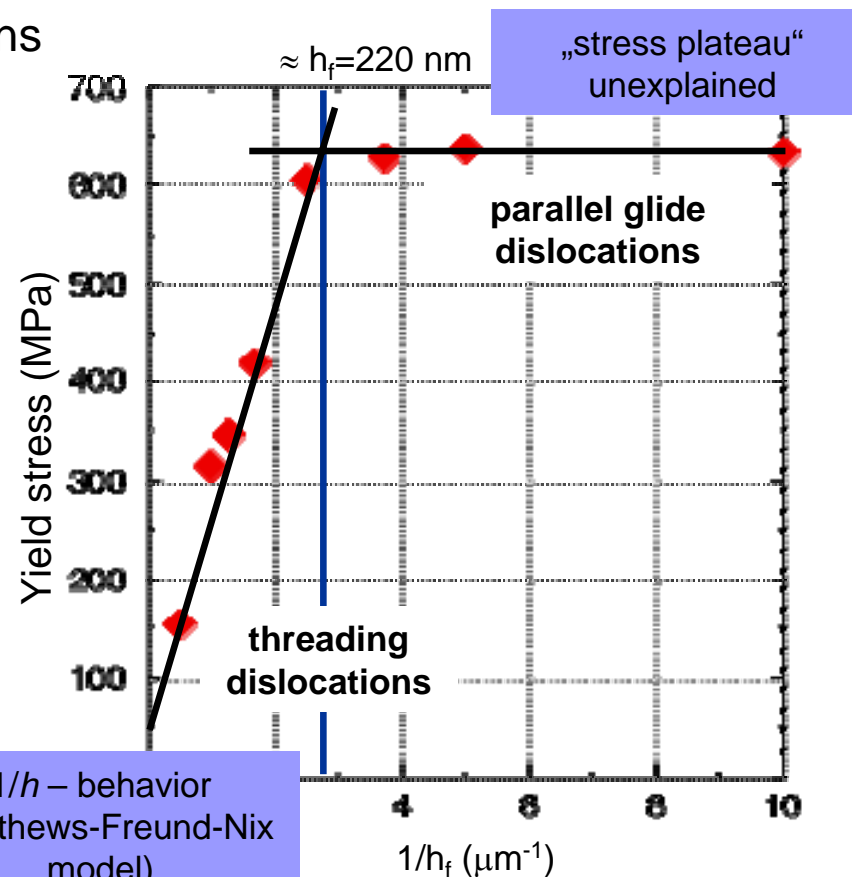
- Biaxial loading by thermal mismatch of film and substrate material: High stresses cause severe problems during operation of the device
- Ultra thin, submicron copper films become critically important in next generation integrated circuits (see, e.g. *Scientific American*, April 2004), MEMS/NEMS



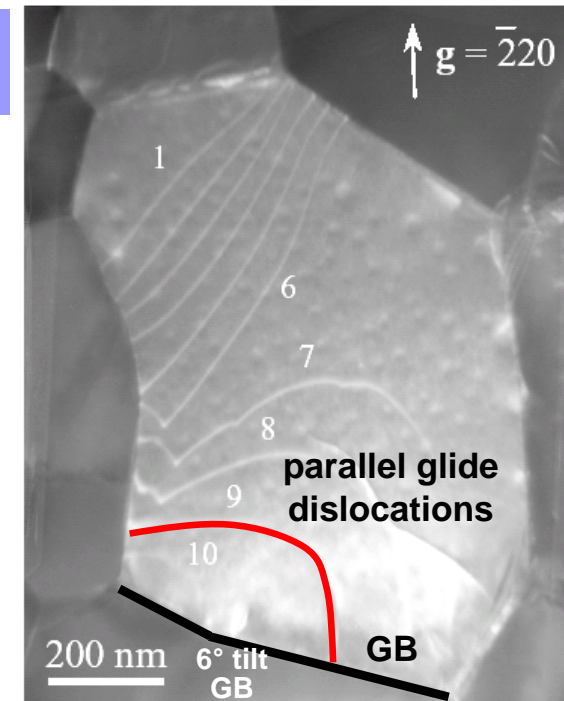
Mechanisms of deformation: Experimental background



(Dehm *et al.* 2002)



Micrometer films

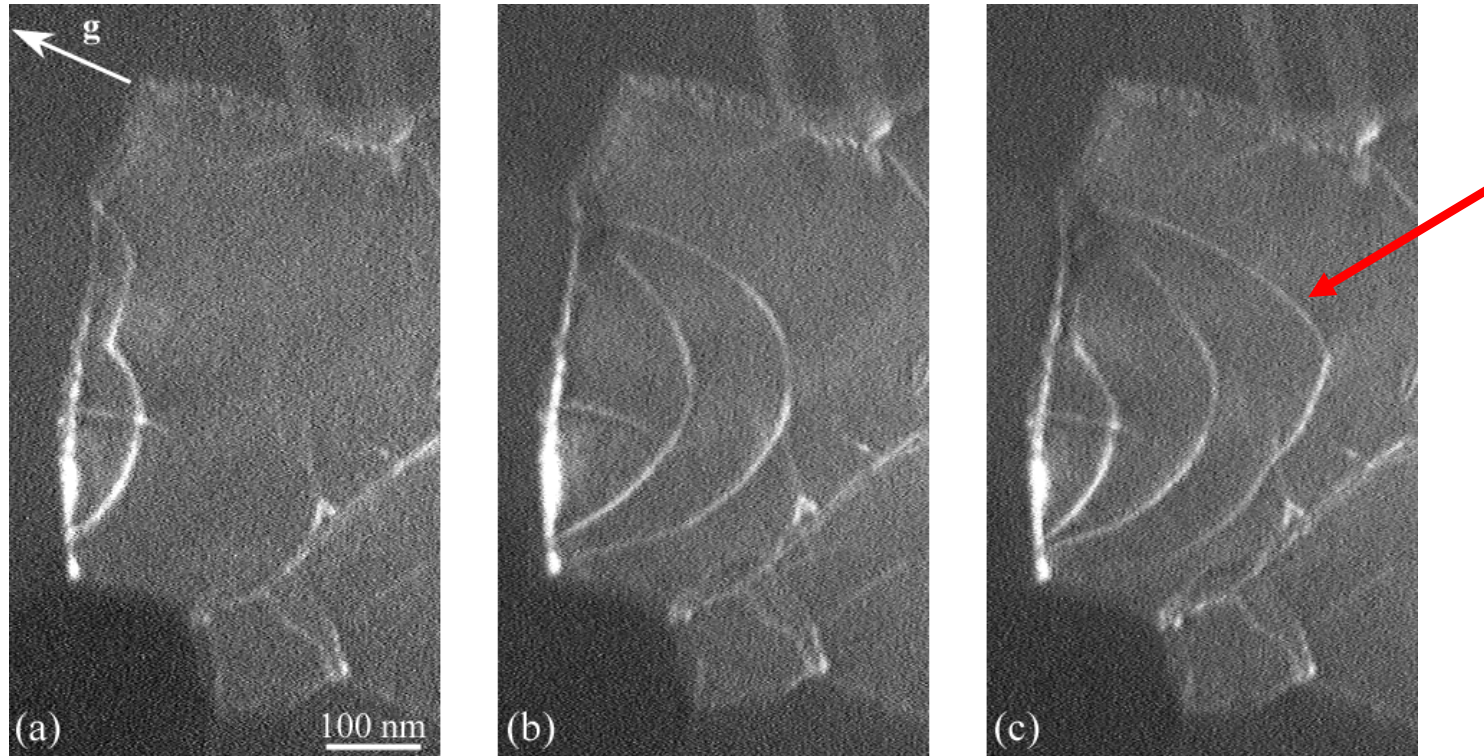


(Balk, Dehm *et al.* 2001, 2002)

Submicron films



Experimental observation of parallel glide



(Dehm, Balk, von Blanckenhagen, Gumbsch, Arzt, 2002)

Plateau regime (suspected deformation mechanism)

- Surface and grain boundary diffusion with subsequent nucleation of dislocations on parallel slip planes (seen below $h=400$ nm)
- Driving force: inhomogeneous stress through grain boundary diffusion (Gao, Zhang, Nix, Thompson, Arzt, 1999)



Continuum model: Constrained diffusional creep

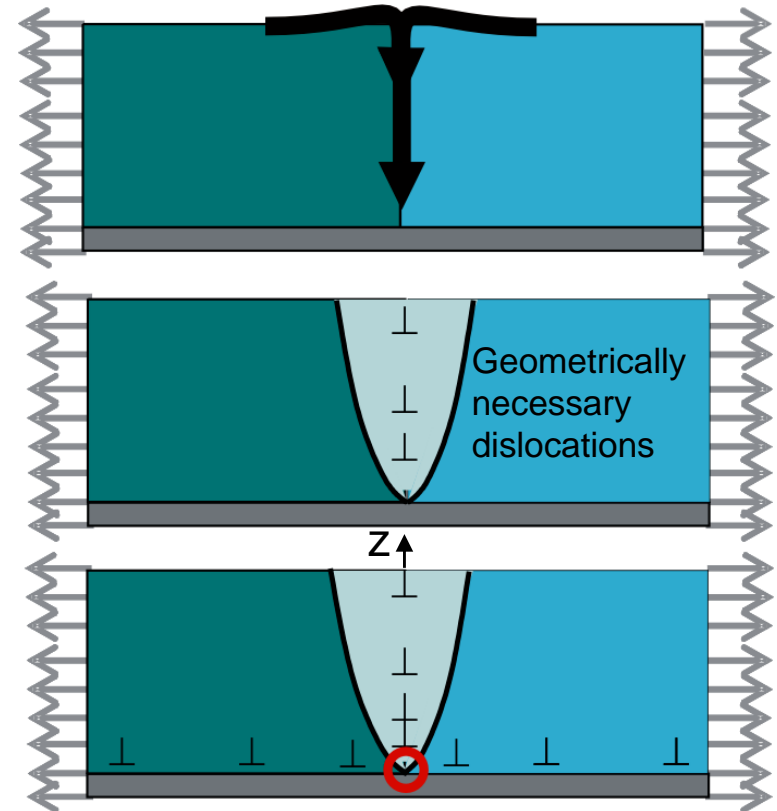


Gao *et al.*, *Acta Mat.* (1999):

Step 1: To relax stress, surface atoms diffuse into the grain boundary

Step 2: Form a pileup of climb dislocations
Crack-like diffusion wedge

Step 3: Emission of parallel glide dislocations at the root of the grain boundary



$$\frac{\partial \sigma_{gb}(z, t)}{\partial t} = \frac{ED_{gb}\delta_{gb}\Omega}{4\pi(1-\nu^2)kT} \int_0^{h_f} S(z, \zeta) \frac{\partial^3 \sigma_{gb}(\zeta, t)}{\partial \zeta^3} d\zeta$$



Continuum model: Constrained diffusional creep

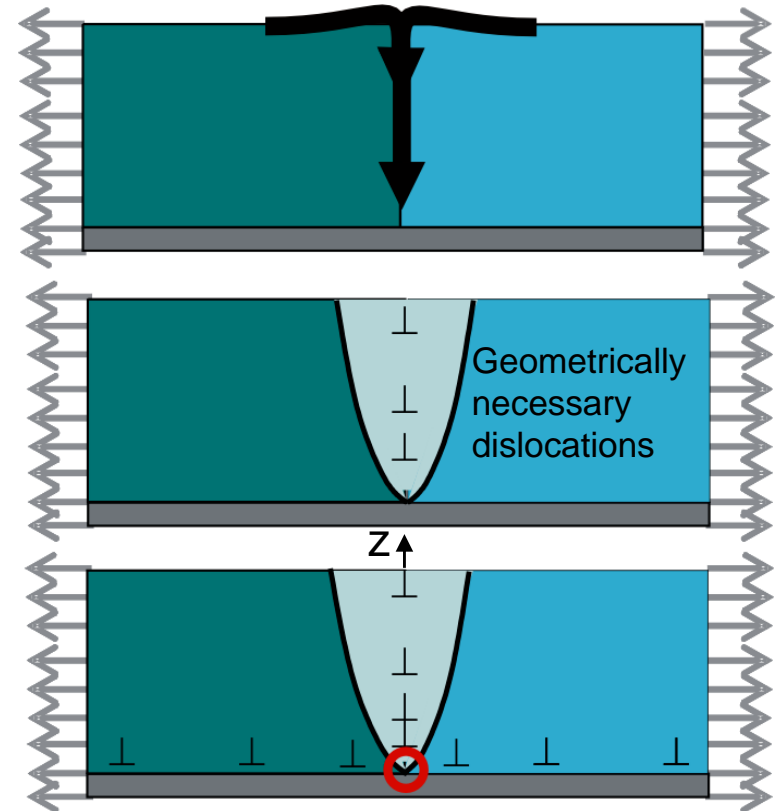


Gao *et al.*, *Acta Mat.* (1999):

Step 1: To relax stress, surface atoms diffuse into the grain boundary

Step 2: Form a pileup of climb dislocations
Crack-like diffusion wedge

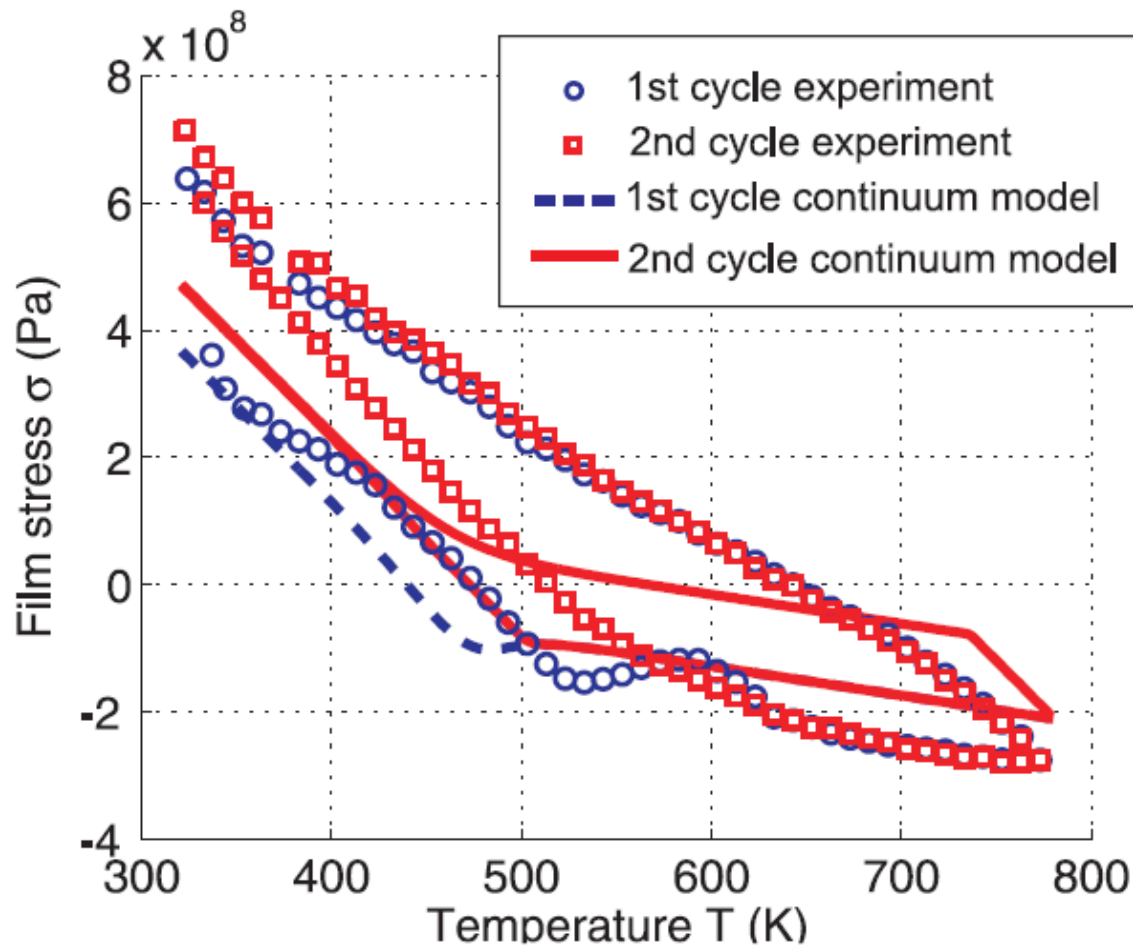
Step 3: Emission of parallel glide dislocations at the root of the grain boundary



Goal: Develop atomistic modeling of these mechanisms to gain further insight into mechanisms



Thermal cycling experiments



➤ Compare continuum model with threshold stress to the experimental data of thermal cycling (Buehler *et al.*)

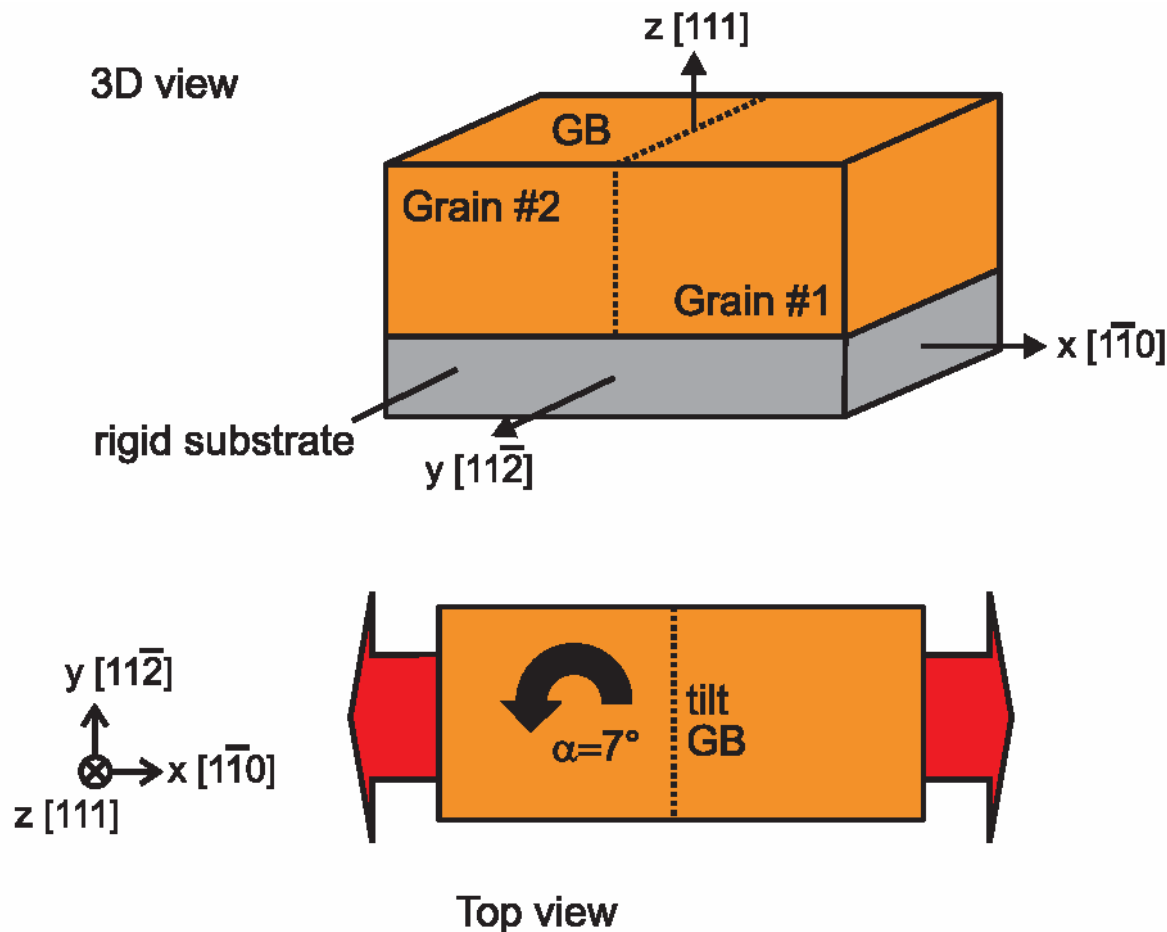
The film thickness is

$$h_f = 100 \text{ nm}$$

➤ Measure stress in thin copper film during thermal cycling



Atomistic model

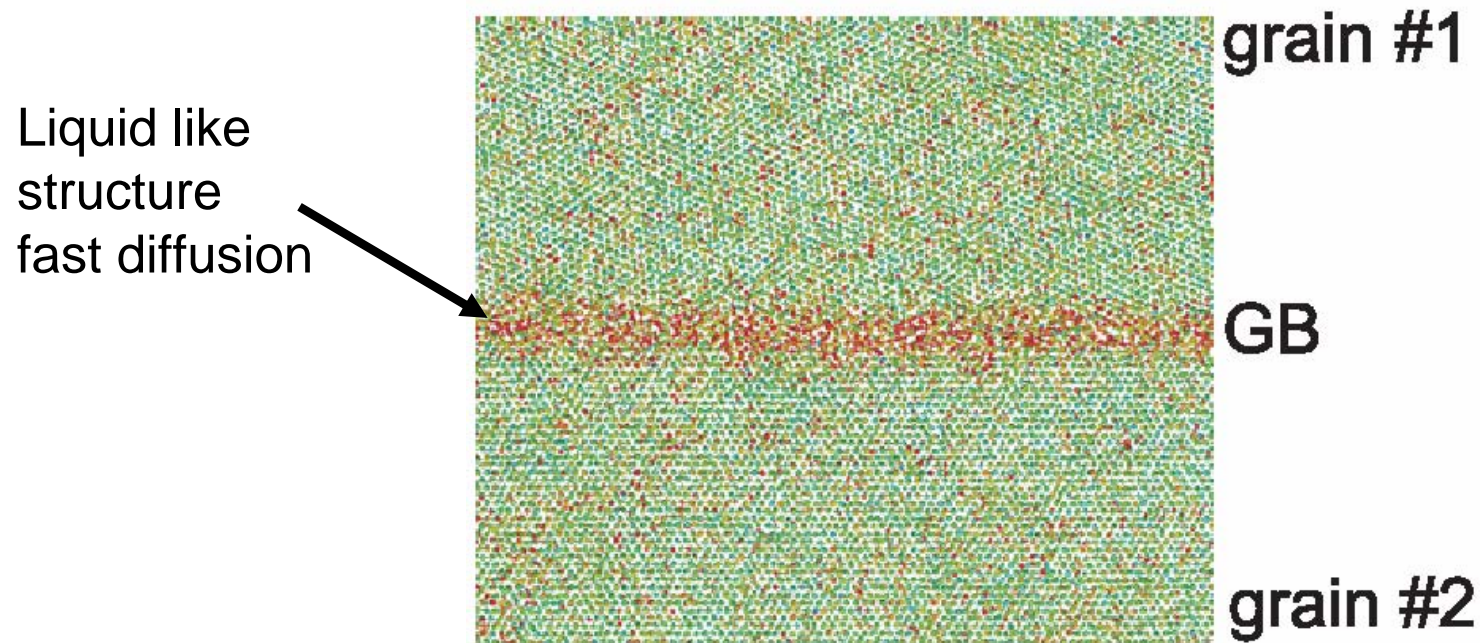


- Copper atoms deposited on a rigid substrate (atoms constrained)
- Use Mishin's EAM potential for copper
- 80%..90% of melting temperature to allow modeling of diffusion with MD at ns timescale (Wolf *et al.*, 2001)+ construct high energy GB

Loading applied by displacing the outermost rows of atoms



Liquid-like grain boundary



($T=85\%$ of melting temperature)

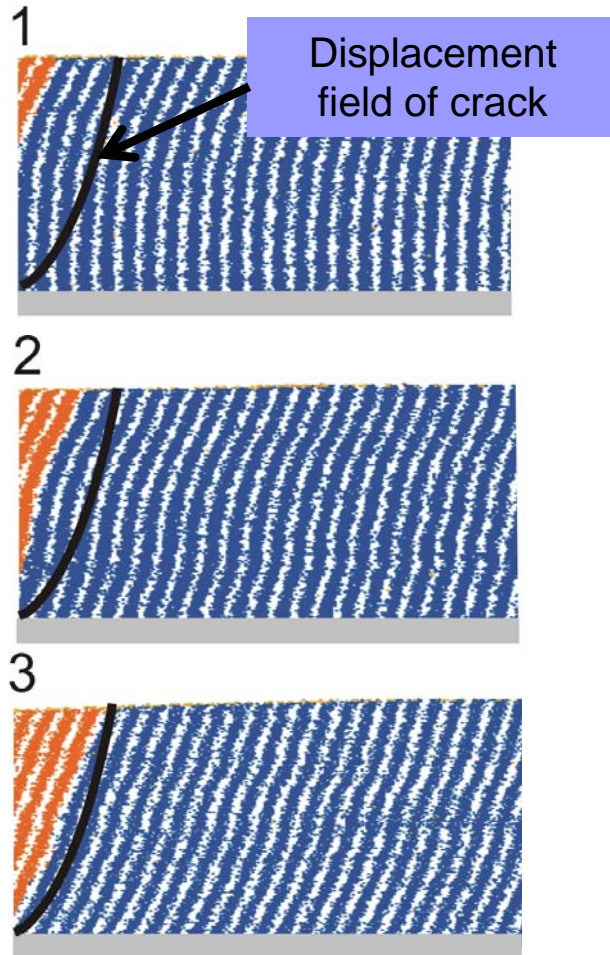
- We find glassy, liquid-like GB structure at elevated temperatures
- This allows modeling of GB diffusion with molecular dynamics (limited to nanosecond time scale)



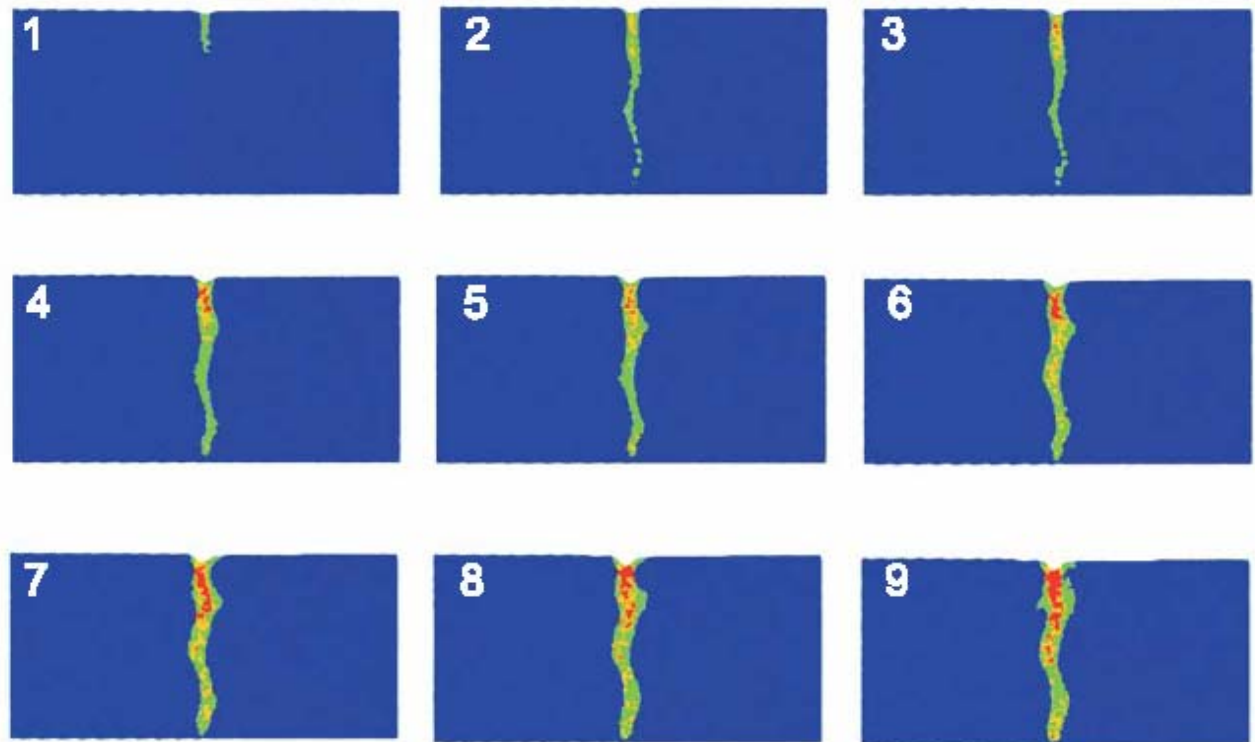
Formation of the diffusion wedge



Climb of edge dislocations in the GB



➤ Formation of crack-like field can be correlated with mass transport along GB (towards substrate):

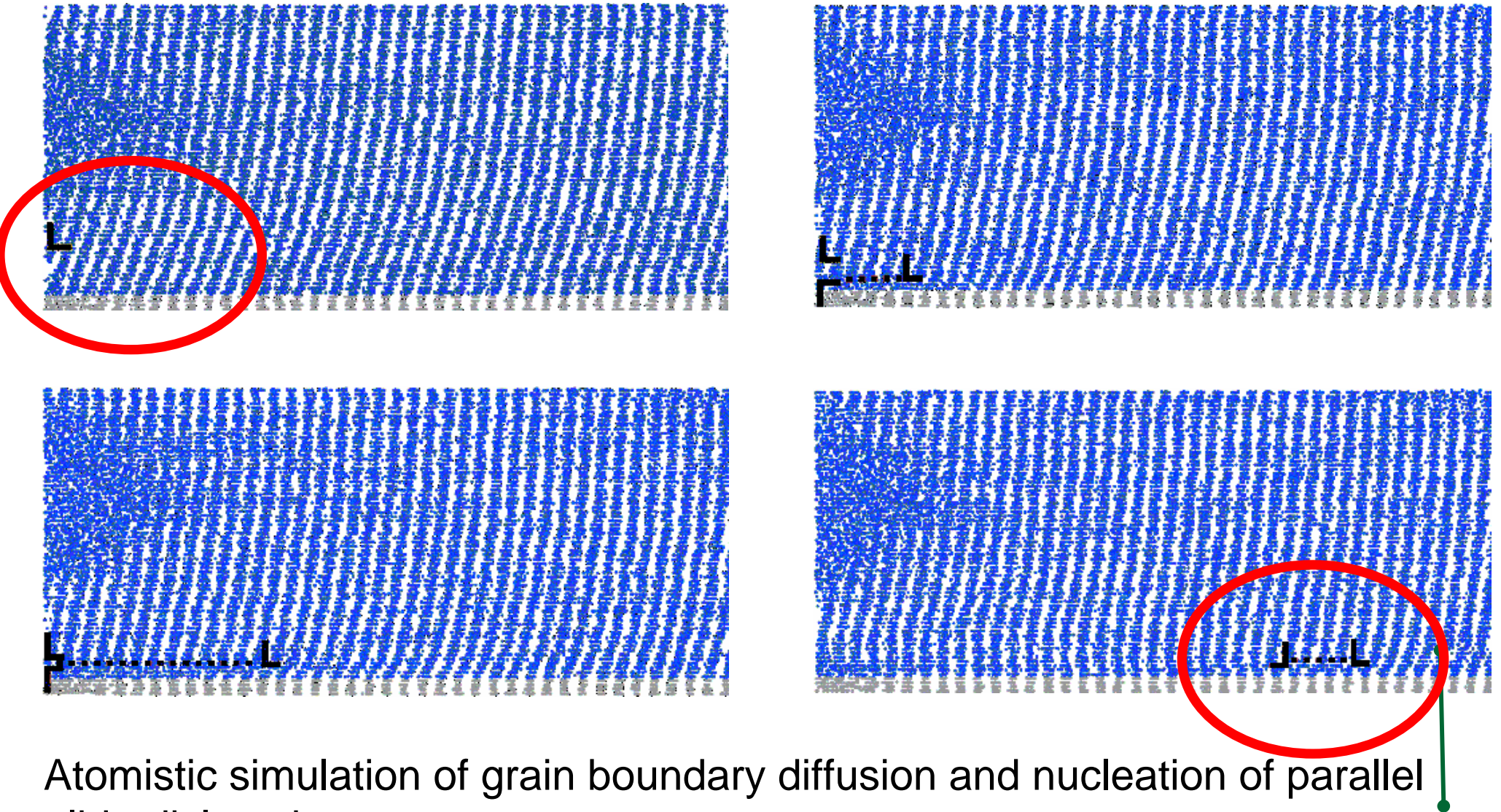


Diffusive displacement along GB
toward the substrate

➤ As material is transported into the GB, the field becomes increasingly crack-like



Nucleation of PG dislocations



Atomistic simulation of grain boundary diffusion and nucleation of parallel glide dislocations

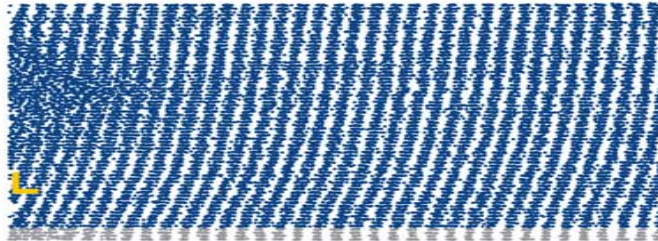
Lattice planes viewed along
[211]



Nucleation of PG dislocations: Diffusion wedge versus crack



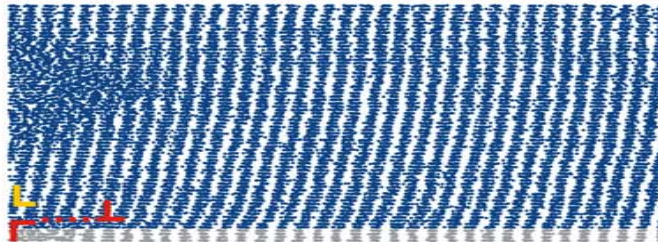
Diffusion wedge



Crack



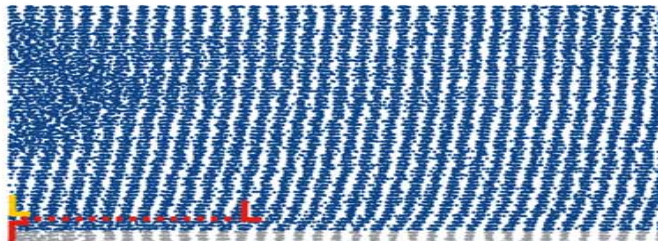
Dislocation
dipole



Incipient
dislocation



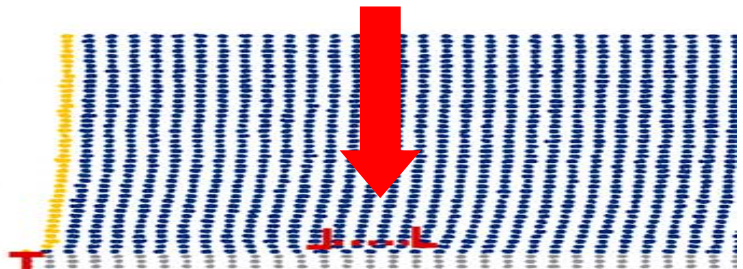
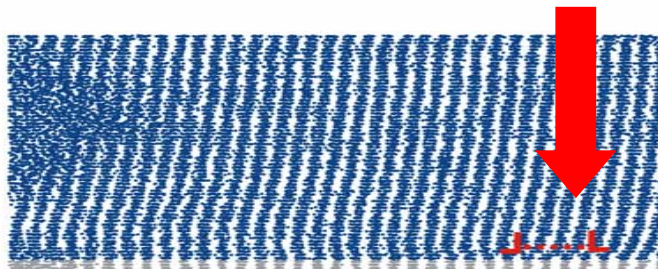
Annihilation



Crack
blunting



Repulsion
Nucleation





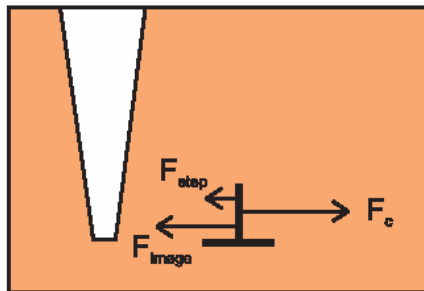
Critical SIF cracks versus diffusion wedge



T (K)	h_f (nm)	K^{PG} (MPa \times m ^s)
Crack		
300	27.2	4.95
Diffusion wedge		
1150	27.2	11.91
1250	27.2	11.35
1250	34.2	11.23

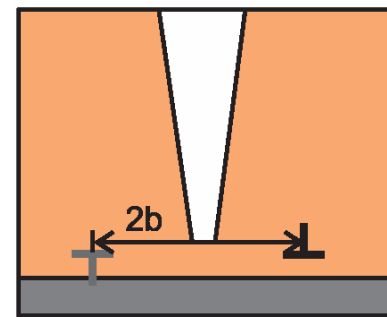
- Concept of SIF is a reasonable concept to link atomistic results to continuum description
- Observe: Critical SIF for diffusion wedge is about twice as large as in the case of a crack

Crack

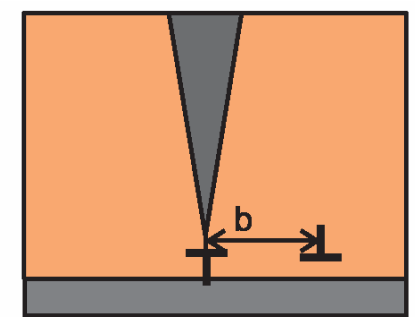


Rice-Thomson model

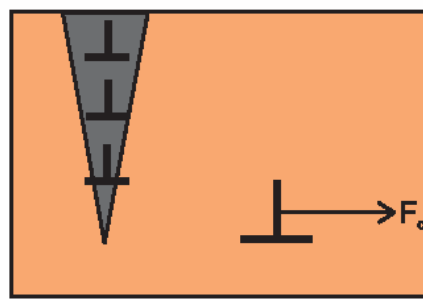
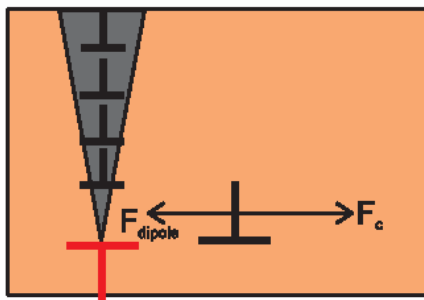
Crack



Diffusion wedge



Diffusion wedge

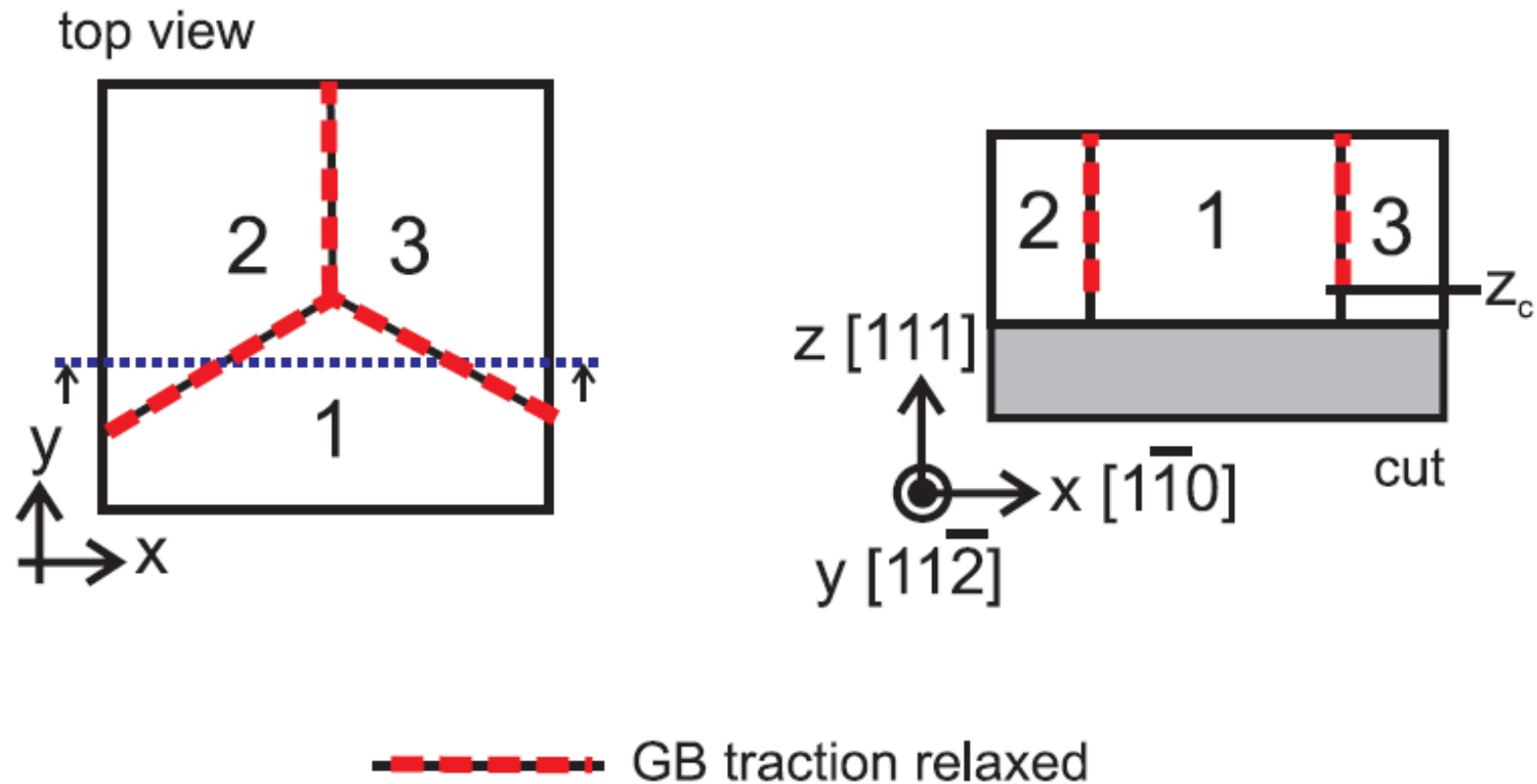


$$K_{cr}^{PG} = \frac{E(2\pi b_x)^s}{8\pi(1-\nu^2)} \quad K_{dw}^{PG} = \frac{E(2\pi b_x)^s}{4\pi(1-\nu^2)}$$

Explains ratio of 2



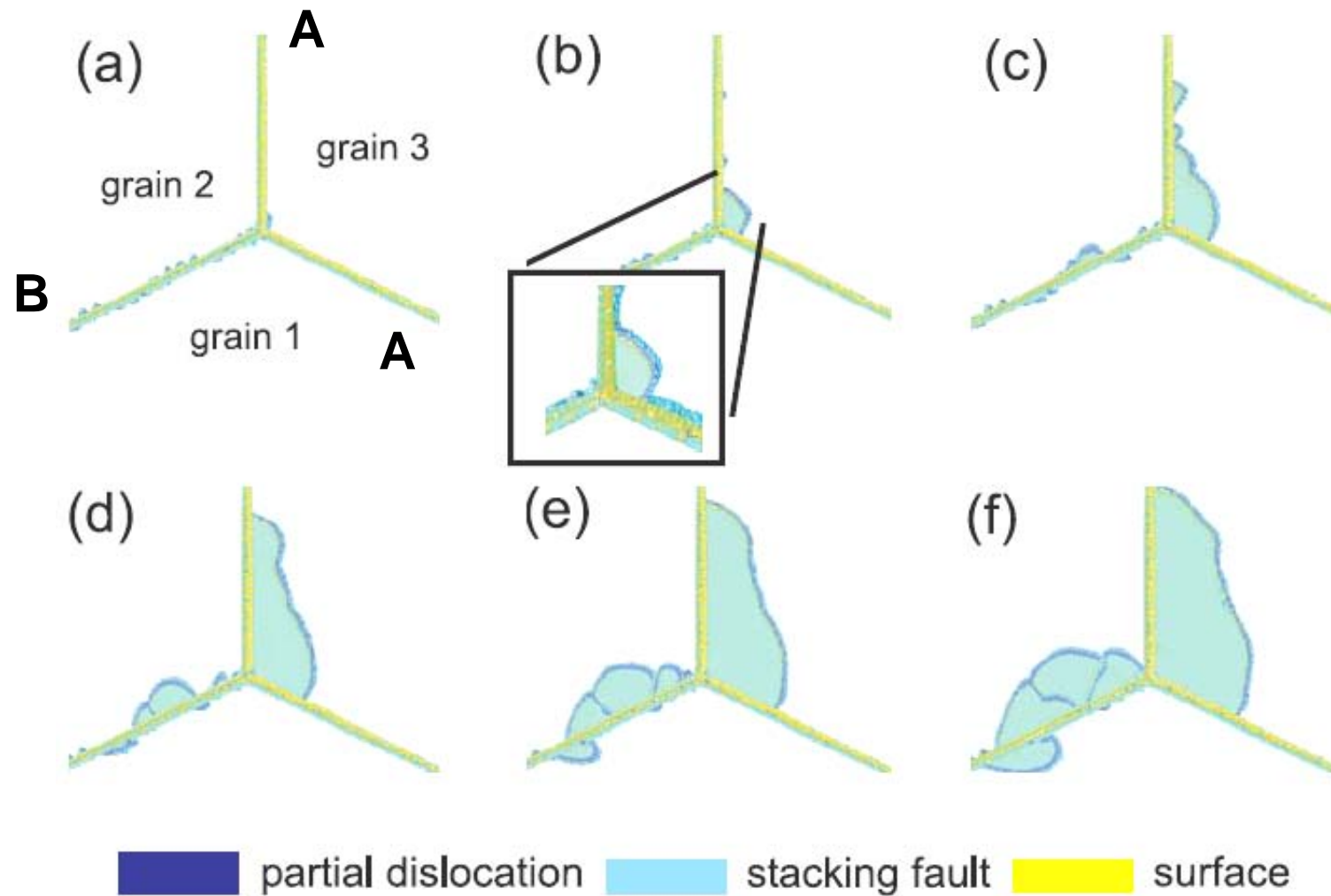
Extension to triple junction model



Build atomistic model of a triple junction with different types of GBs:
High-energy (disordered)-**A** and low-energy (array of dislocations)-**B**



Extension to triple junction model



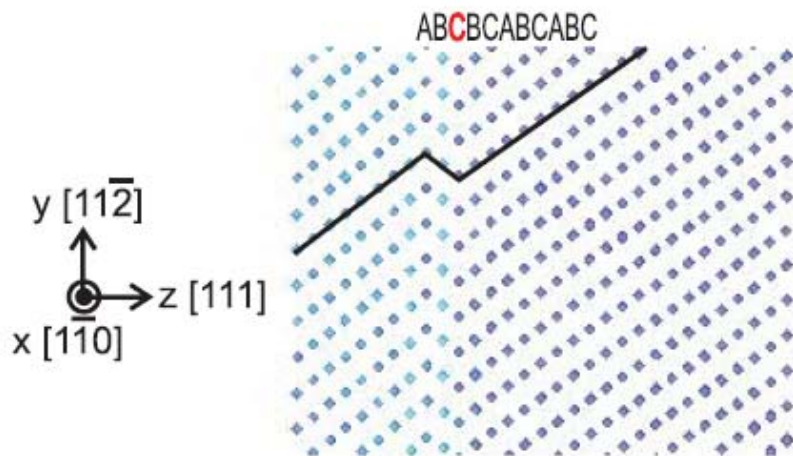
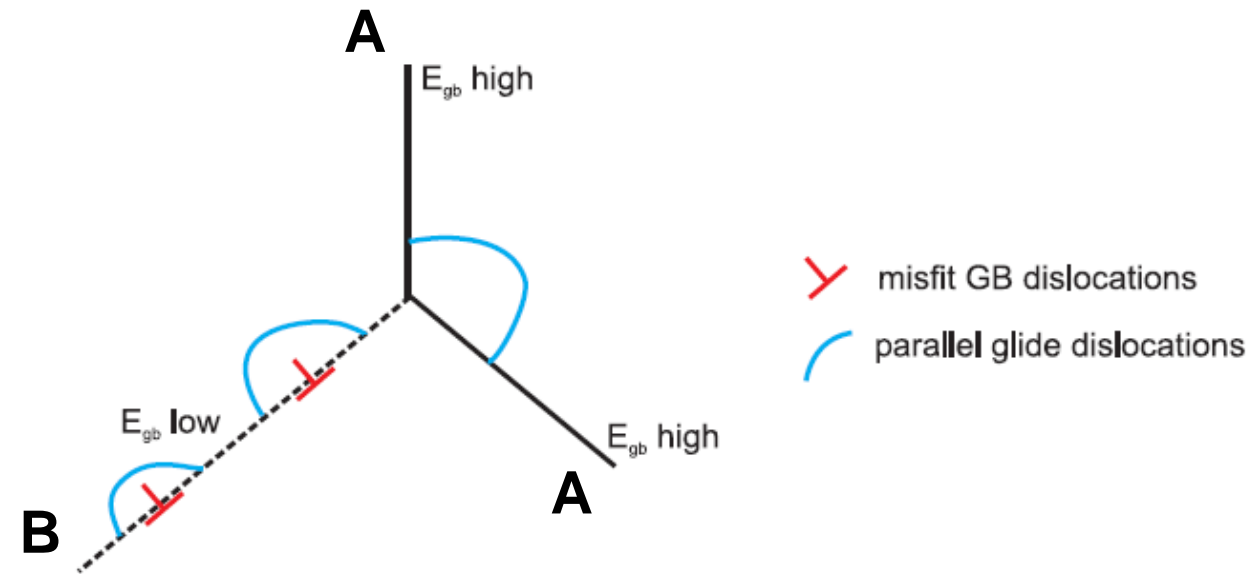
Upon application of biaxial tensile load, observe nucleation of PG dislocations



Misfit GB dislocations to serve as nucleation points for PG dislocations



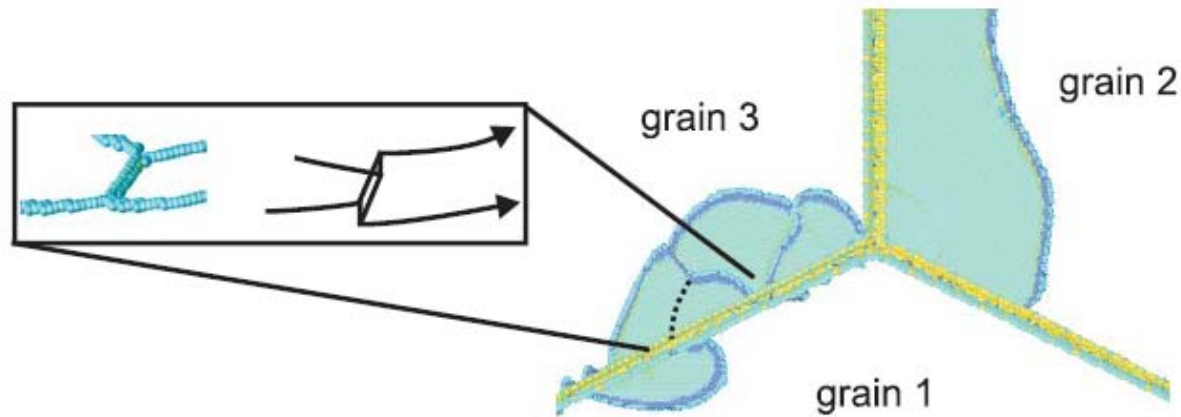
Schematic



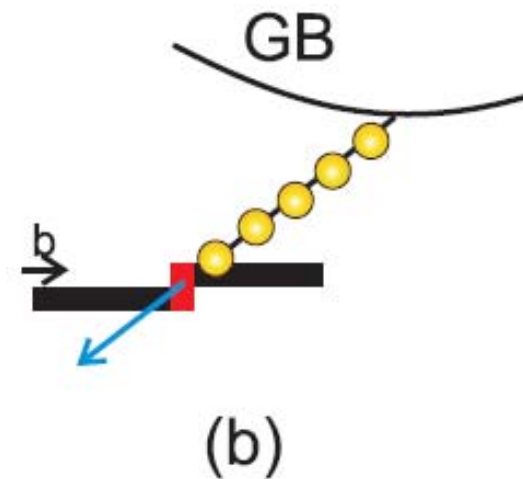
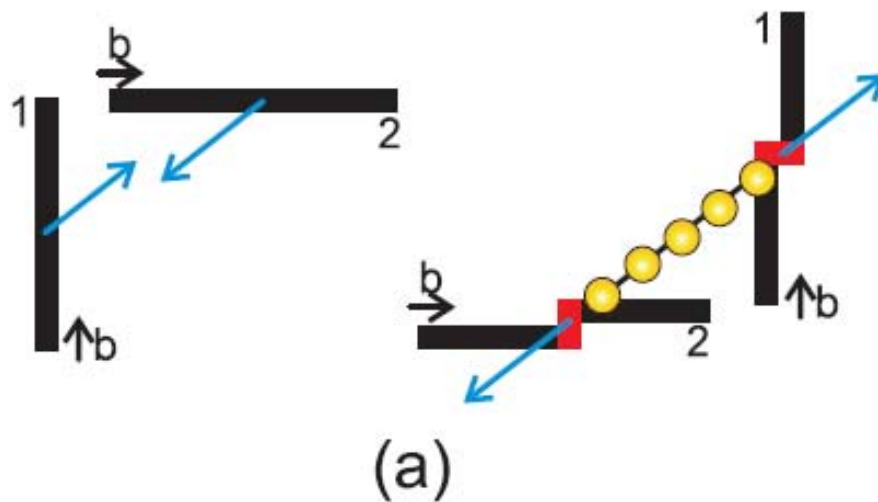
- Deformation twinning by repeated nucleation of partial dislocations.
- Repeated slip of partial dislocations leads to generation of a twin grain boundary.



Formation of jogs: Dislocation reactions



- Dislocation junction and bowing of dislocations by jog dragging.
- A trail of point defects is produced at the jog in the leading dislocation, which is then repaired by the following partial dislocation.

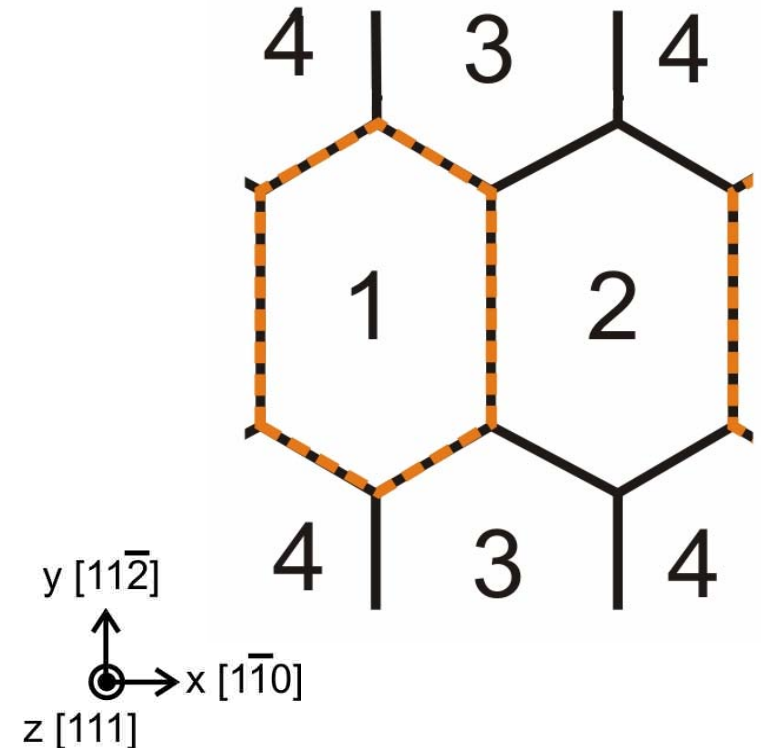
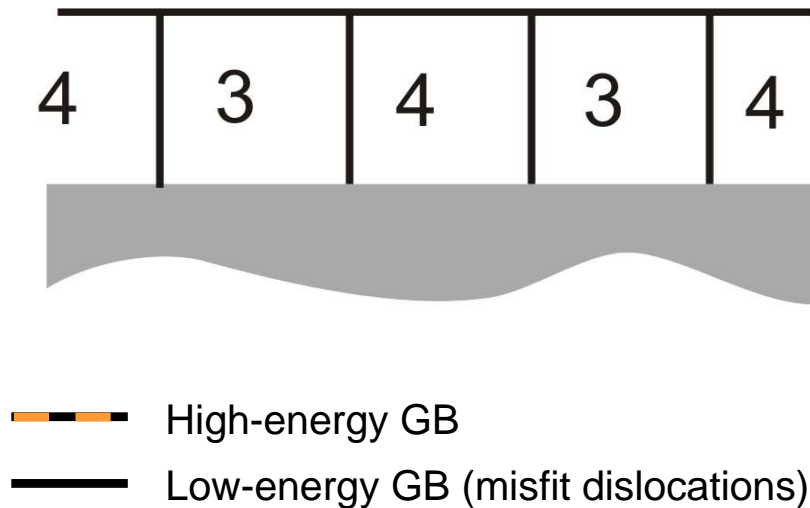




Constrained grain boundary diffusion in polycrystalline models: 3D model



Biaxial loading



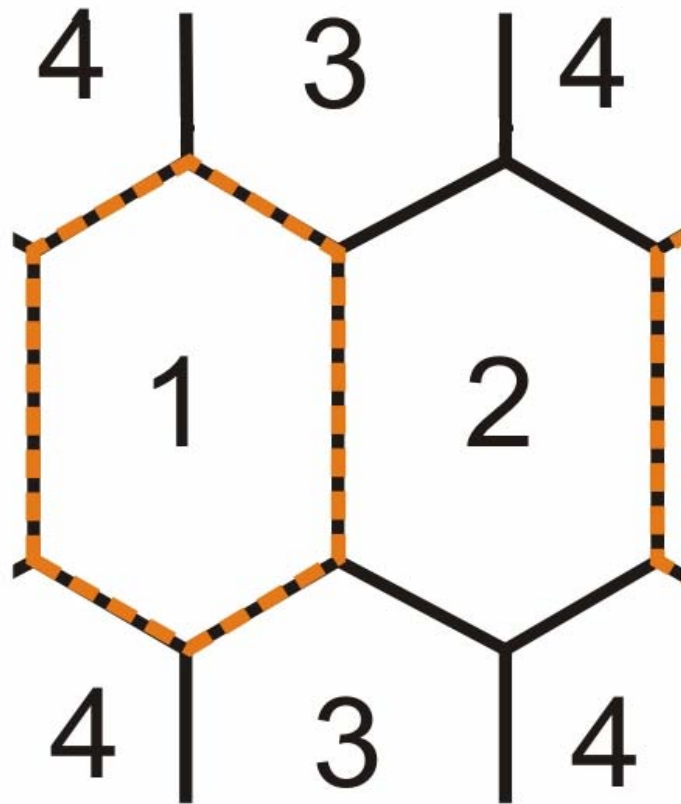
Model:



Polycrystalline sample with low- and high energy grain boundaries (grains rotated around z axis, > 2,000,000 atoms, EAM potential for copper-Mishin *et al.*, ITAP-IMD code)

- Temperature: About 90 % of melting temperature (similar as Yamakov *et al.*)



Constrained grain boundary diffusion in polycrystalline models



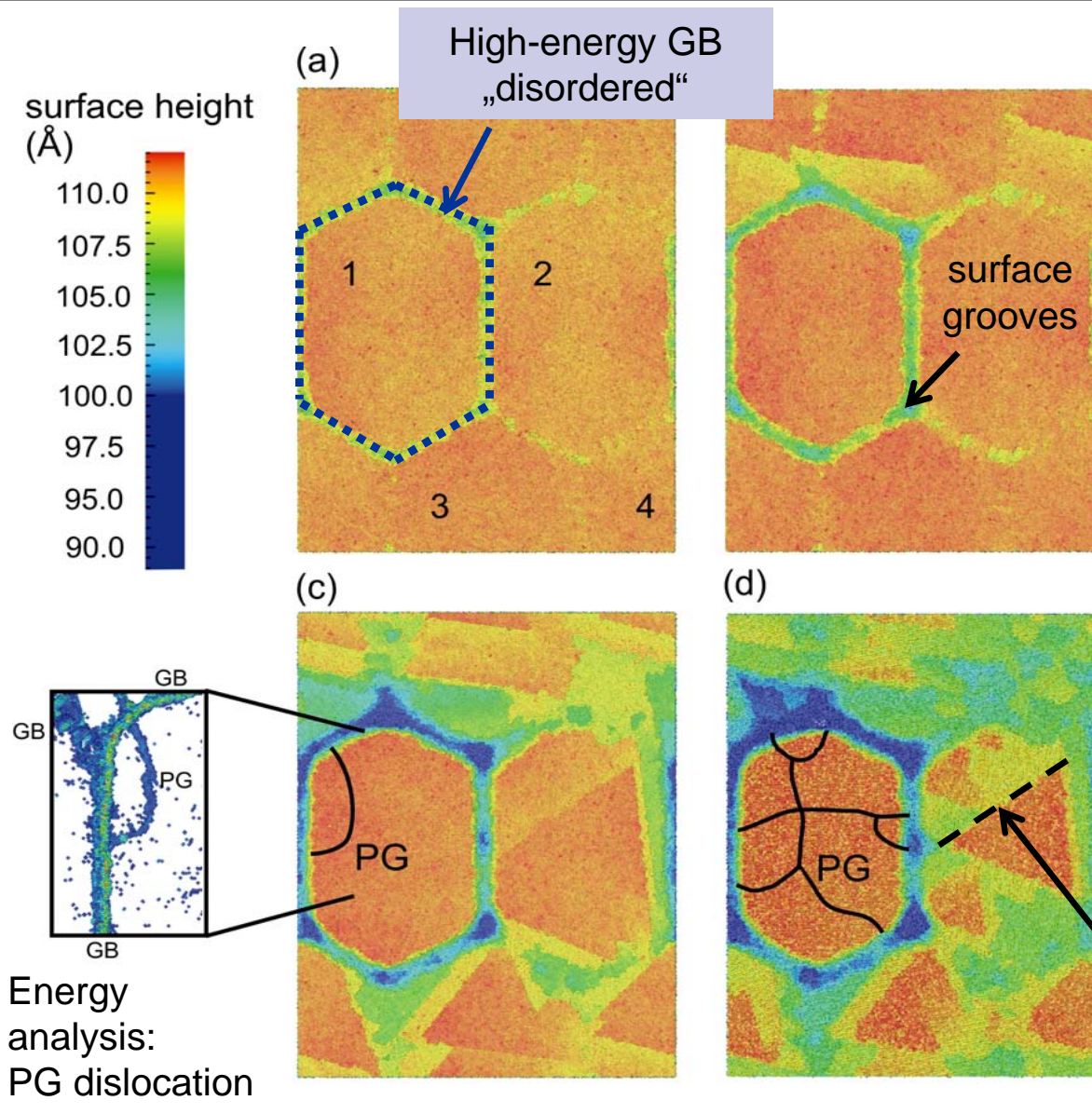
-  High-energy GB
-  Low-energy GB (misfit dislocations)

Theoretical predictions

- Diffusional creep strong along high-energy GBs (Wolf *et al.*), should lead to stress relaxation and development of crack-like stress field, leading to PG dislocations according to Gao (1999)
- Along low-energy GBs, threading dislocations should prevail (since no GB traction relaxation possible by diffusion)



Polycrystalline atomistic model



Main results

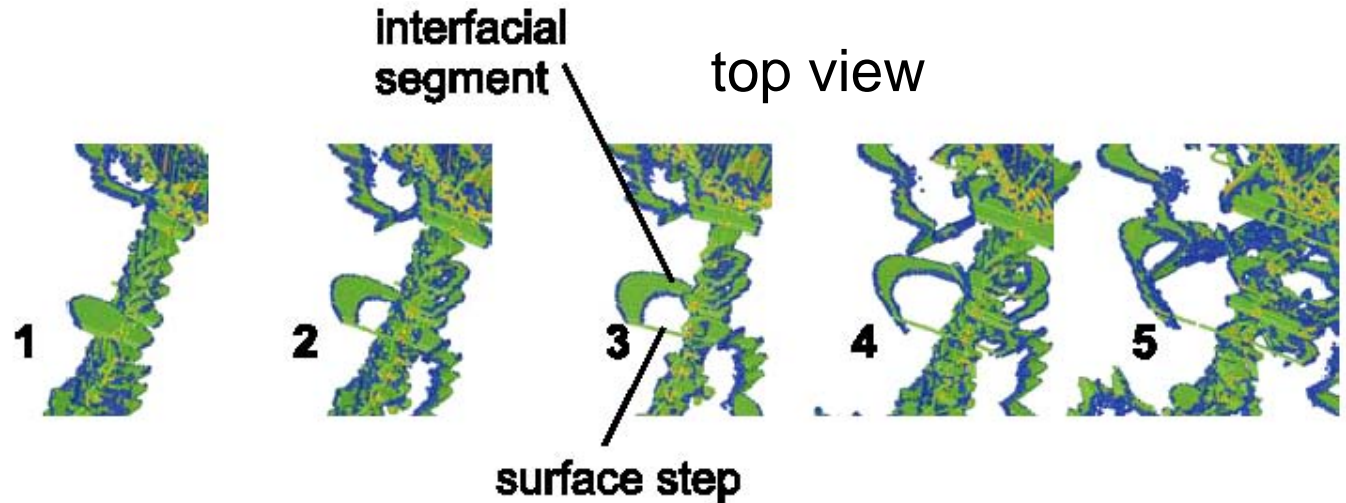
- Diffusion wedges develop preferably at high-energy GBs (fast diffusion paths)
- Diffusion wedges lead to PG dislocations (black lines), otherwise: Threading dislocations.
- No threading dislocations in grain surrounded by high-energy GBs

➤ High-energy GBs: Liquid-like structure – fast diffusion paths

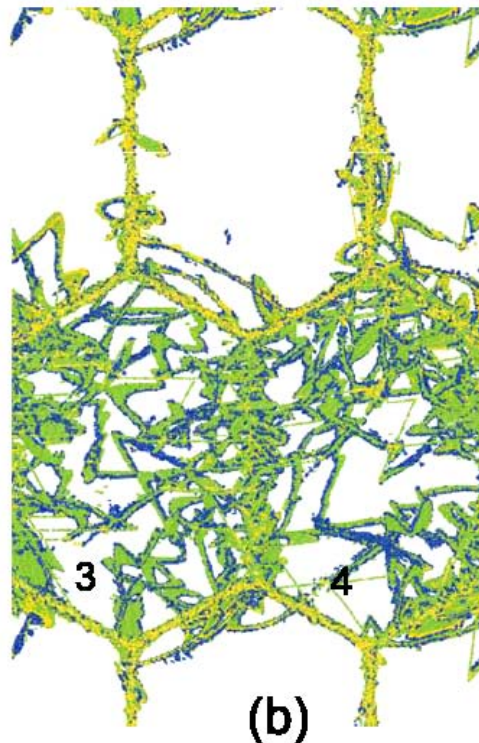
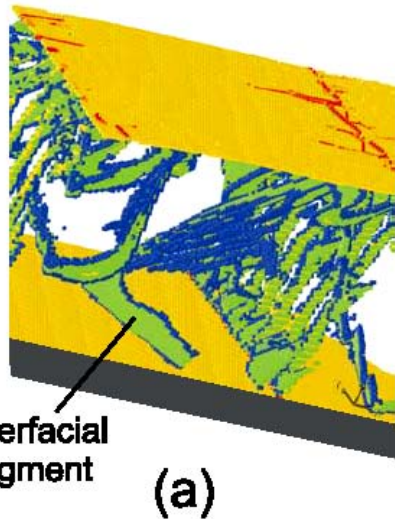


Threading and parallel glide dislocations

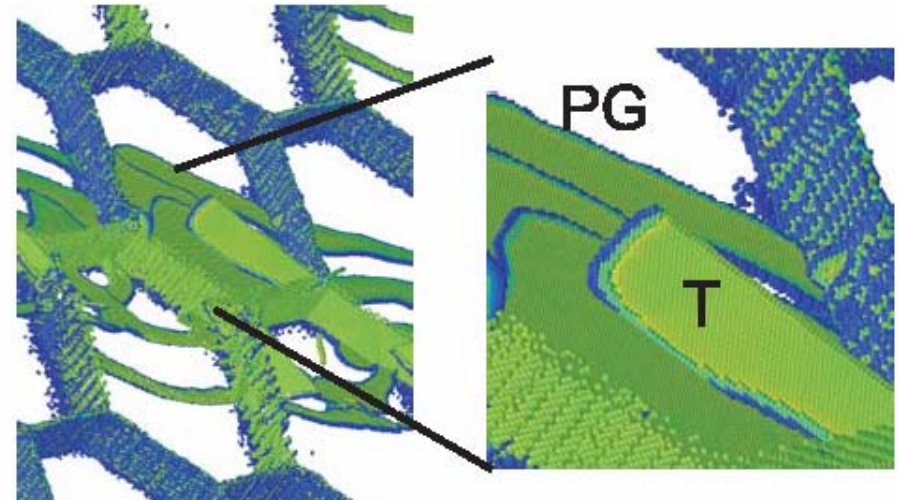
➤ Nucleation of threading dislocations:
Creation of surface steps and interfacial segment



- surface step
- surface
- partial dislocation
- stacking fault

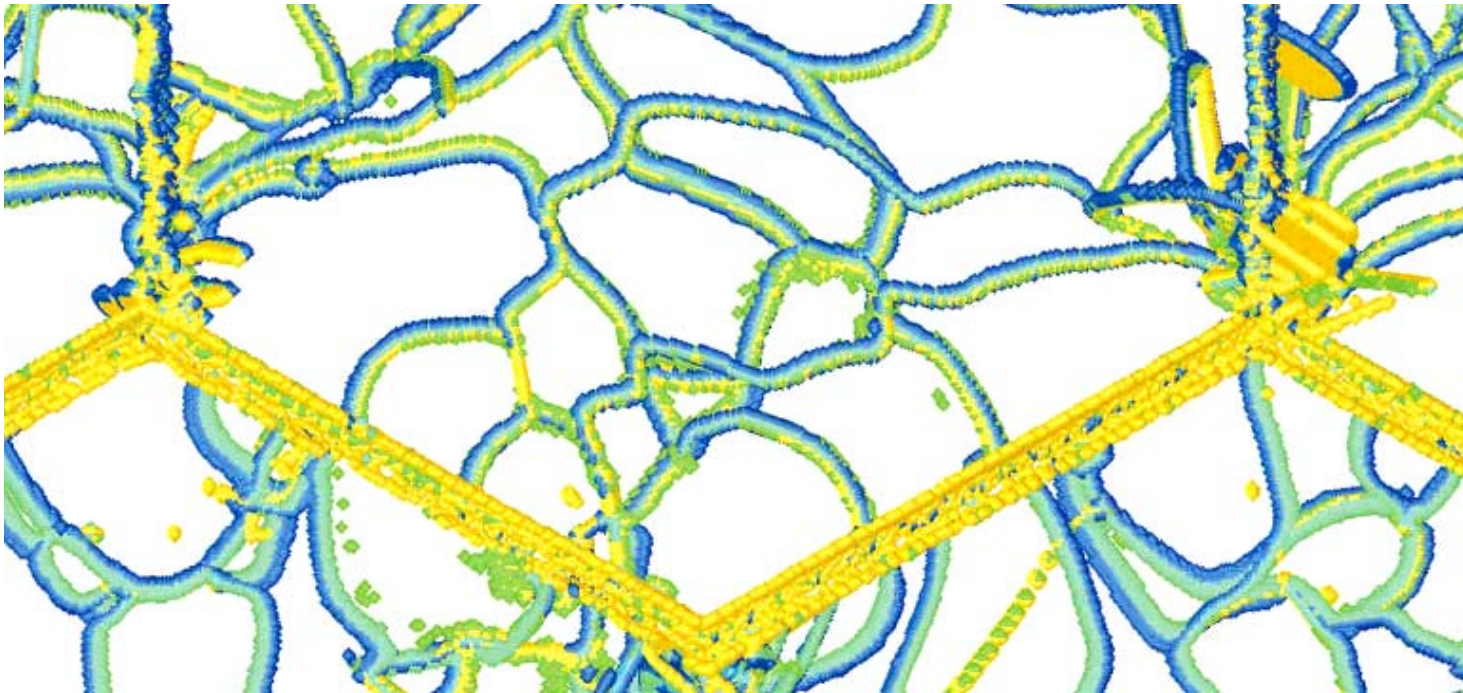


Competition of threading and parallel glide dislocations





Formation of dislocation networks



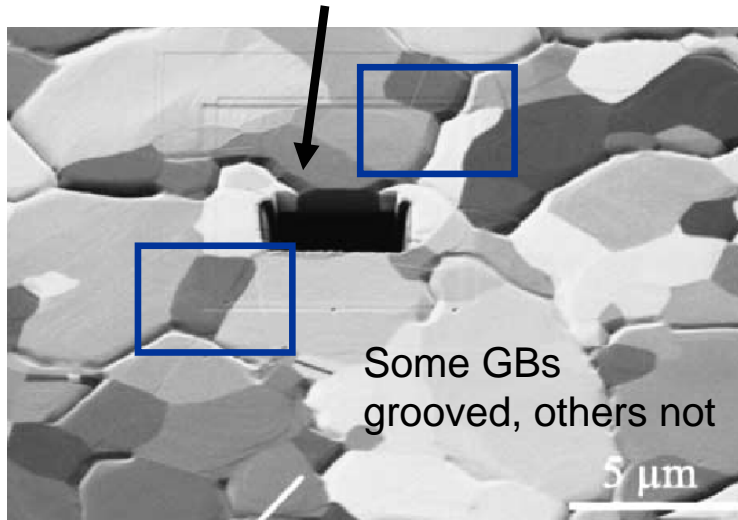
- The plot shows an analysis of the complex dislocation network of partial parallel glide dislocations that develops inside the grains.
- All defects besides stacking fault planes are shown in this plot.



Qualitative comparison of MD results with experiment

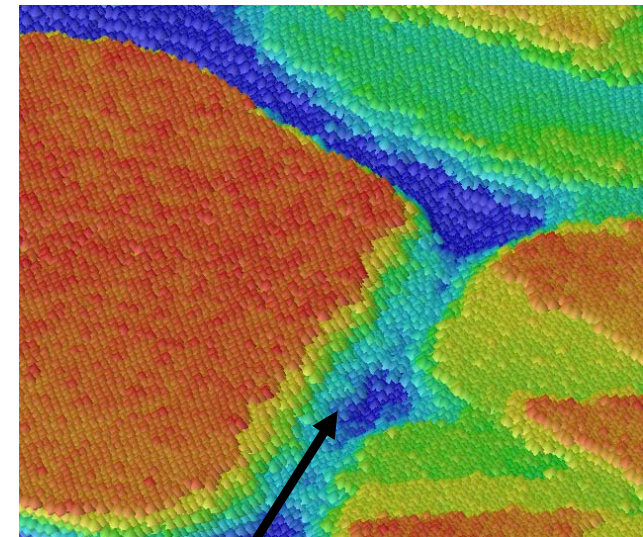


Surface grooves

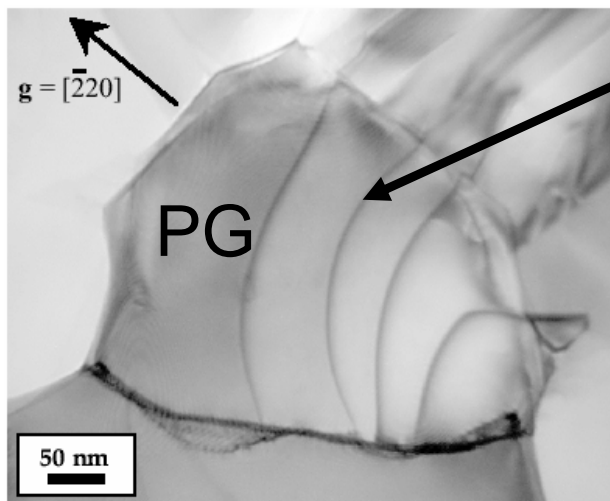


Experiment (Weiss *et al.*)

MD simulation

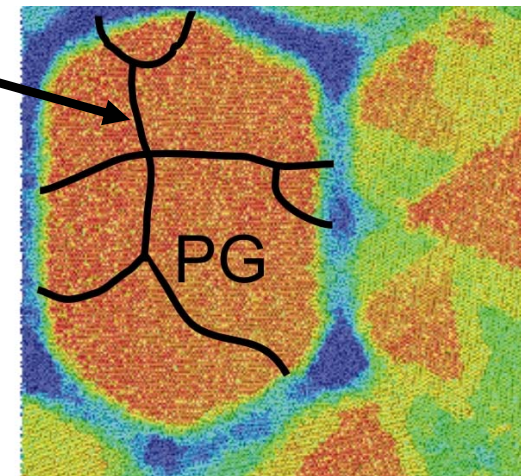


Surface grooves
at specific GBs



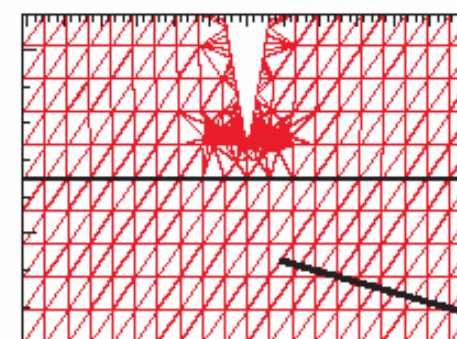
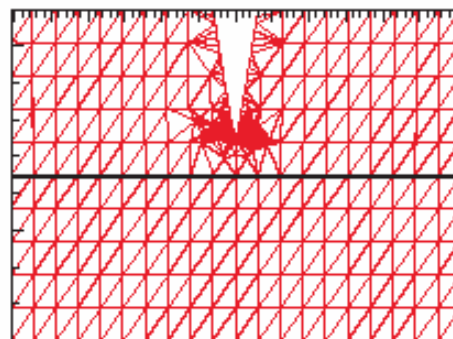
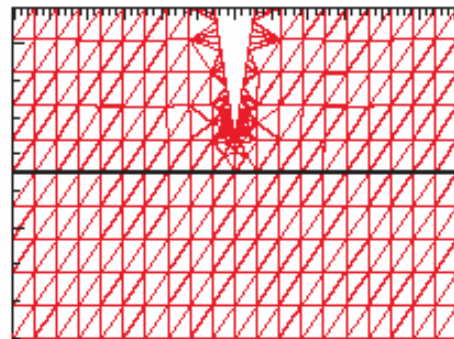
Experiment (Balk *et al.*)

PG
dislocations
in some grains





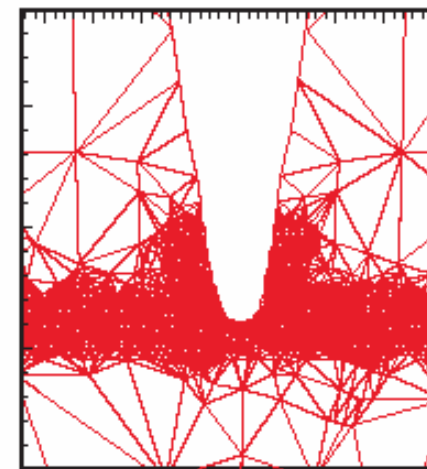
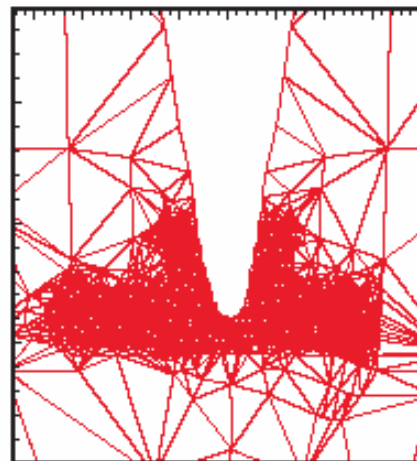
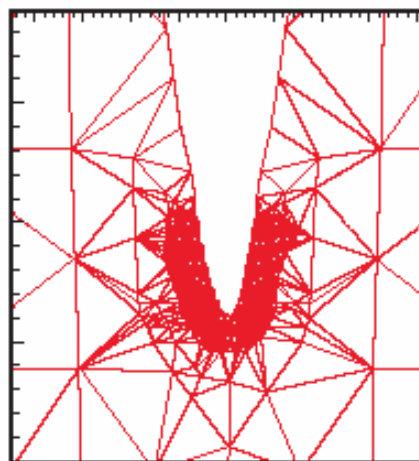
The Quasi-Continuum (QC) Method



Thin copper
film

rigid
substrate

(a)



$y[111]$
↑
+ → $x[110]$

(b)

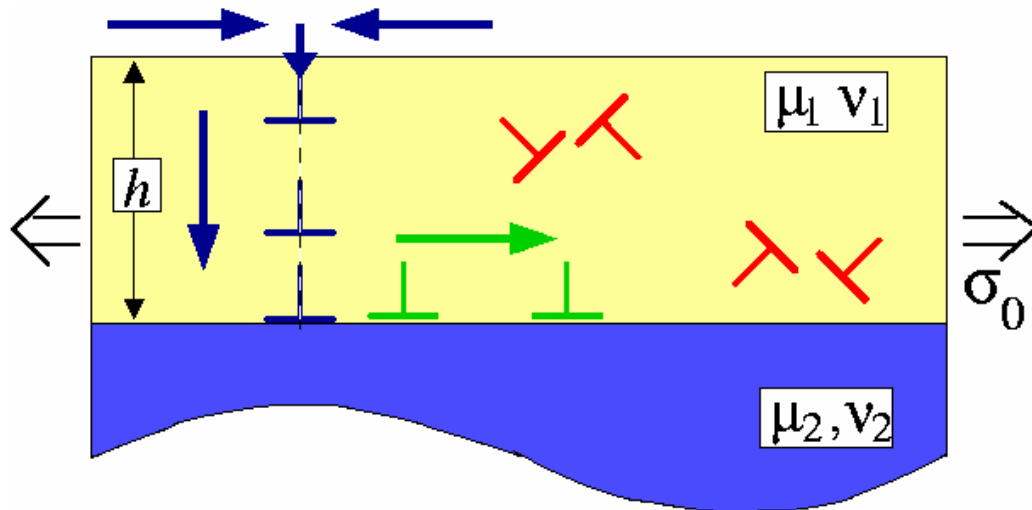
Combine atomistic regions embedded
in continuum region



Mesososcopic model



Dislocations: Sources and sinks of plastic strain

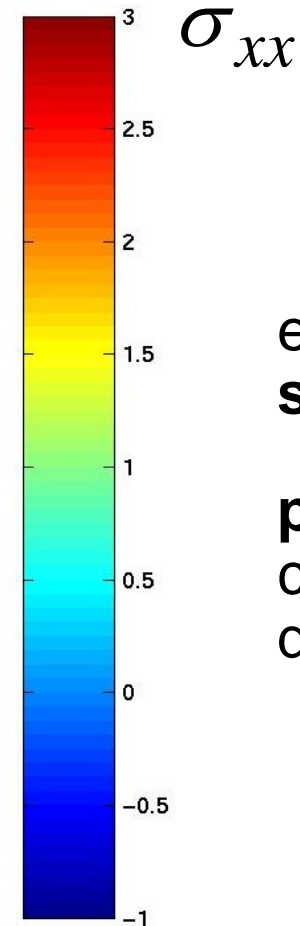
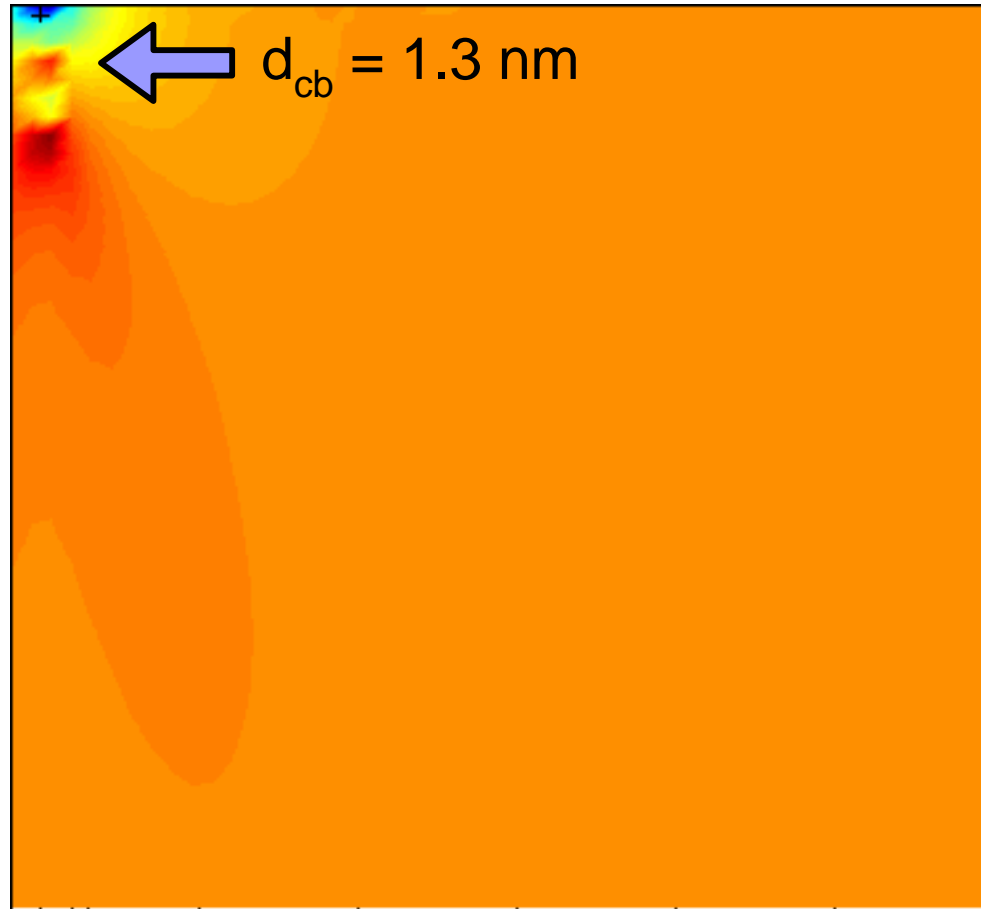


Critical condition for nucleation of PG dislocation from MD simulation:
Critical SIF

- Surface diffusion leads to nucleation of **climb dislocations**.
- Stress concentration at root of grain boundary drives nucleation of **parallel glide dislocations**.
- Slip on **inclined glide planes** is *conventional* deformation mechanism.



Mesososcopic model: Movie



elastic straining to **initial stress level**

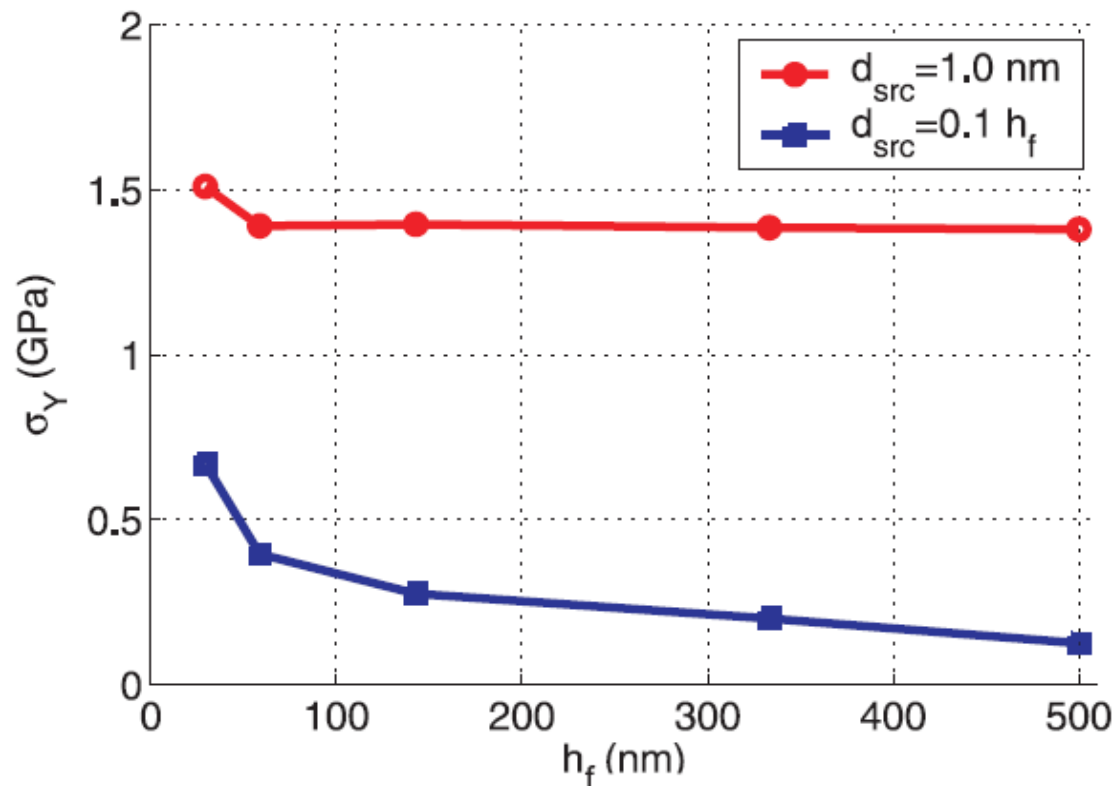
plastic relaxation under constant lateral displacement

↑ Glide source position adapted to MD results

↑ Dislocations are absorbed in grain boundary (high energy grain boundaries)



Flow stress versus film thickness

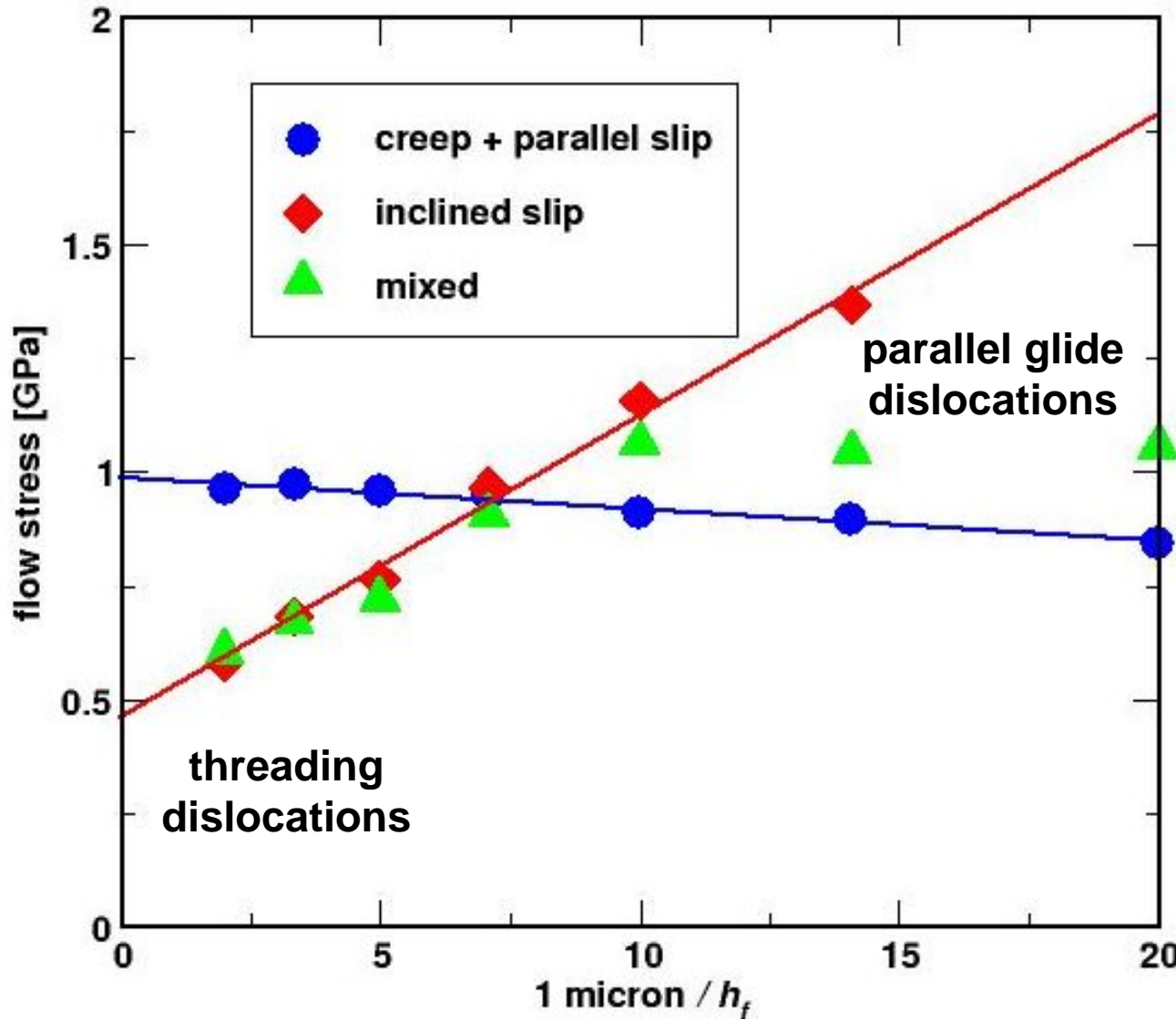


- Flow stress σ_Y versus the film thickness h_f , as obtained from mesoscopic simulations of constrained diffusional creep and parallel glide dislocation nucleation.
- The results are shown for two different initiation criteria for diffusion (constant source and therefore local criterion as proposed in equation, and a film dependent source).
- In the case of a local criterion for diffusion initiation, the yield stress is film-thickness independent as observed in experiment by Balk, Arzt *et al.*



Competing mechanisms: Slip versus diffusion

DDD modeling (mesoscale)



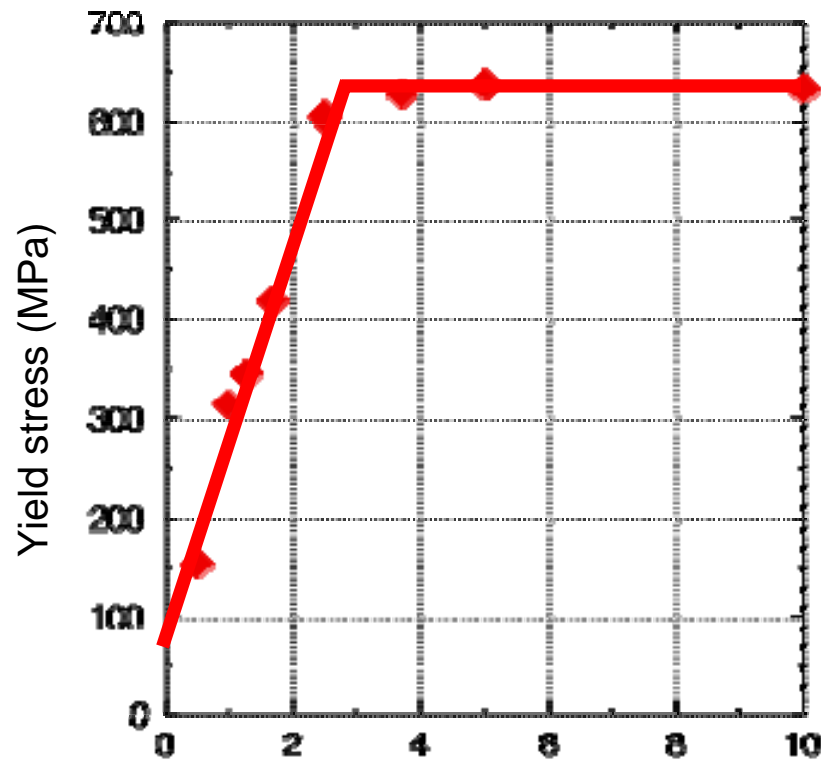
✓ Creep mechanism yields constant (or slowly decreasing) flow stress

✓ Inclined slip yields linear strengthening with inverse film thickness

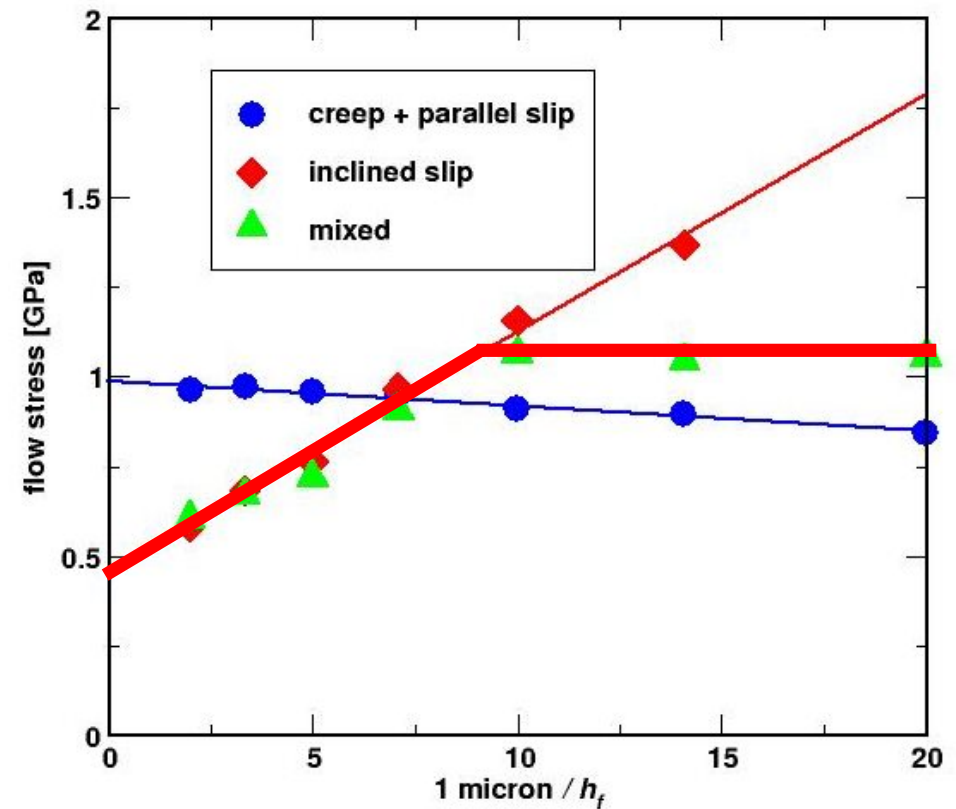
✓ Deformation mechanisms interact (inclined slip shuts down creep mechanism)



Comparison: Experiment versus modeling



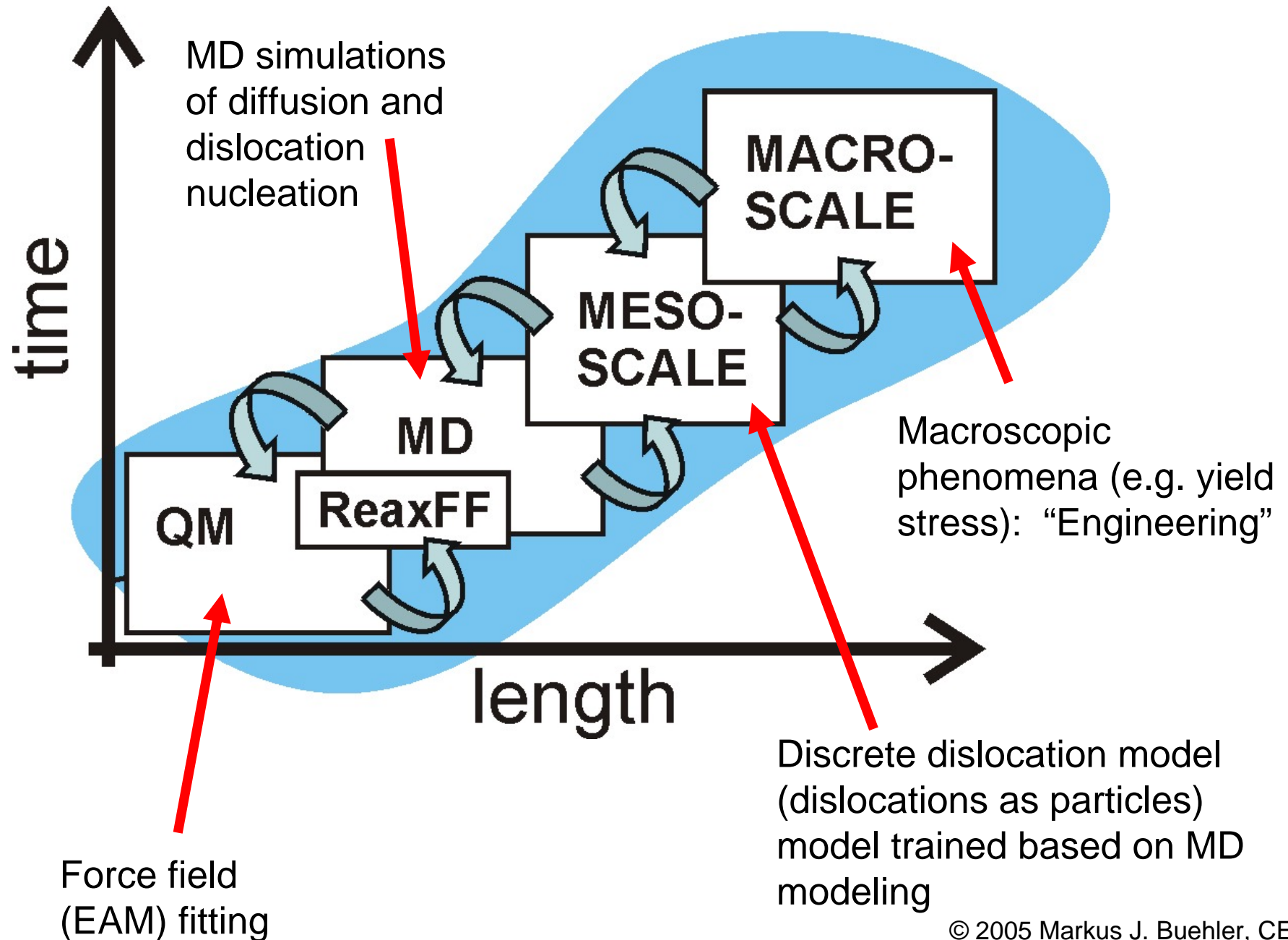
Experiment
(Balk, Dehm, Arzt)



Atomistic based mesoscale model

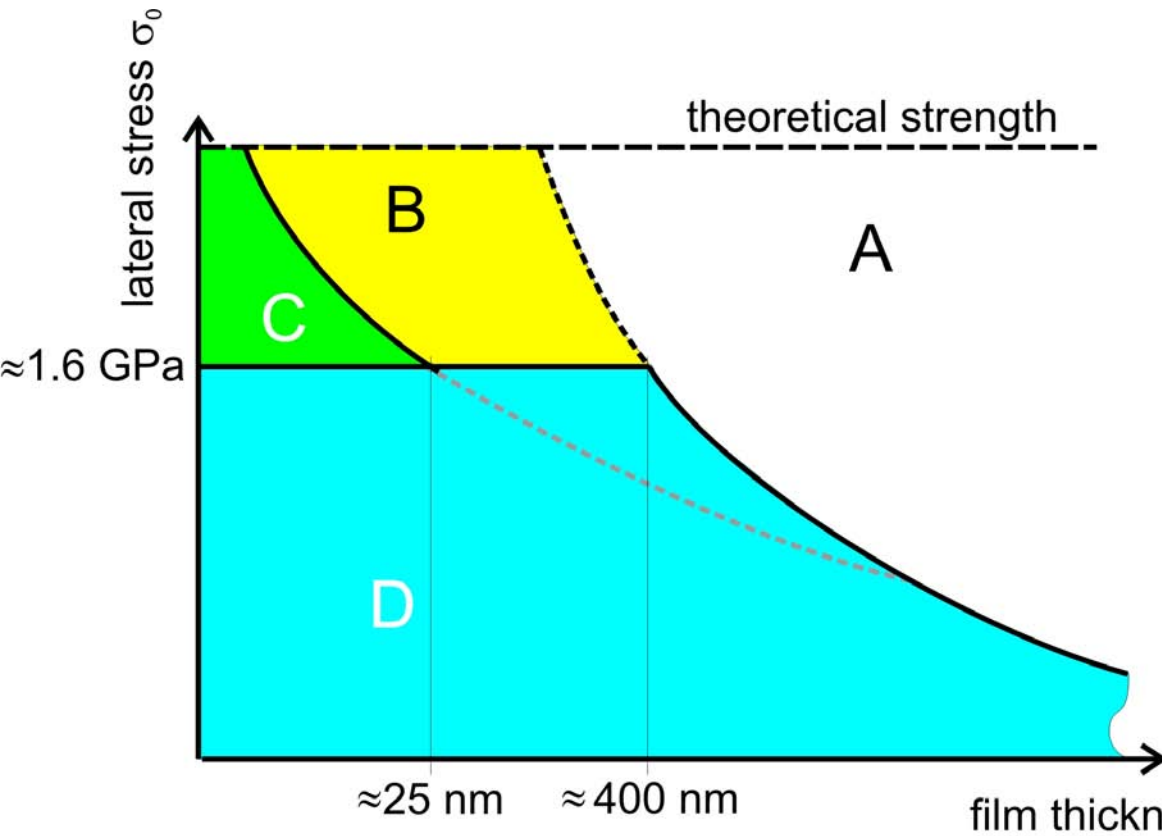


Hierarchical multi-scale approach





Deformation map of submicron copper films



Deformation mechanism map *

A-Threading dislocations (Nix)—
"classical"

B-Constrained diffusional creep
with parallel glide dislocations

C-Diffusional creep

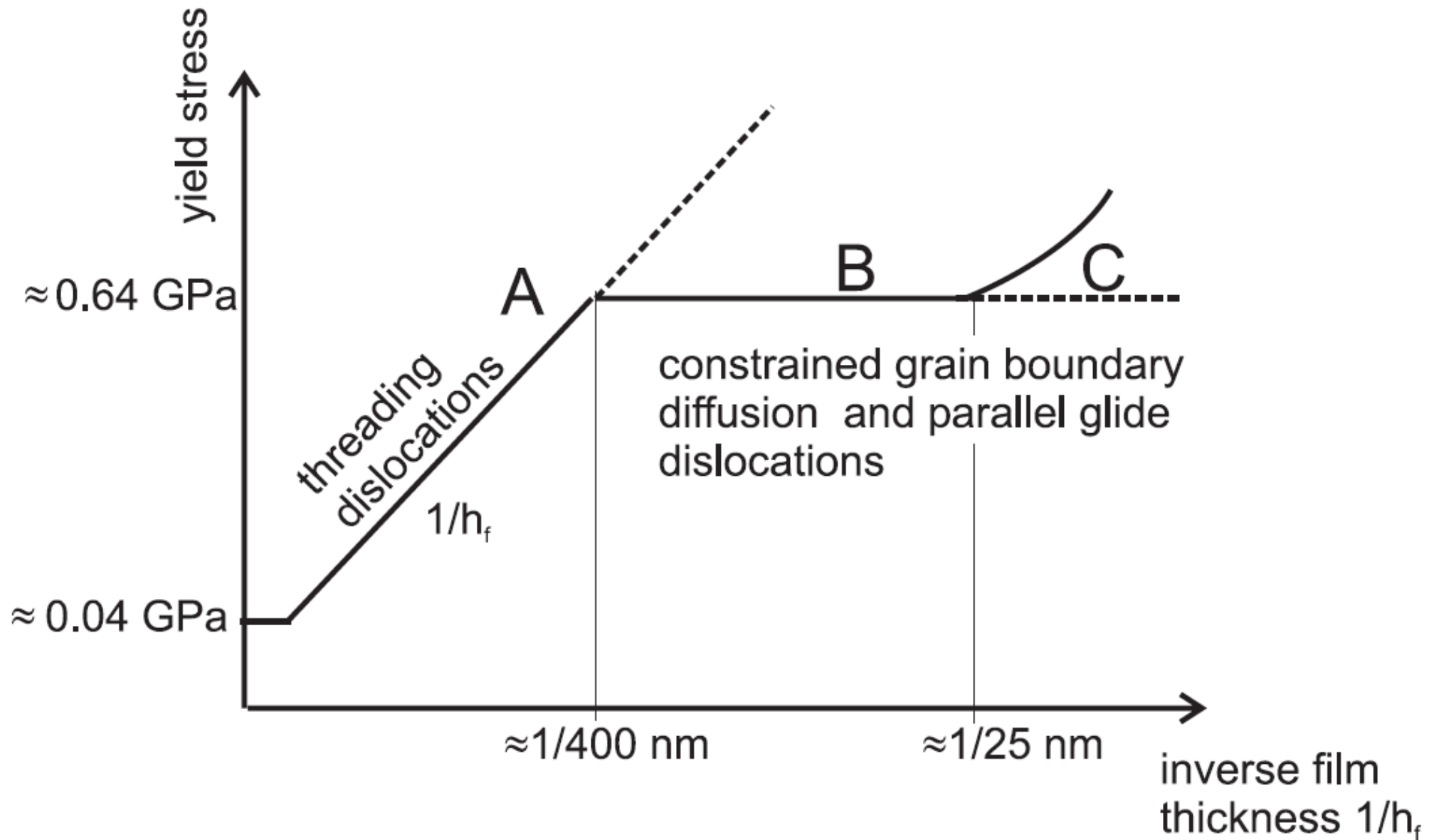
D-No stress relaxation
mechanism

➤ **Conclusion:** In ultra thin copper films without capping layer, constrained grain boundary diffusion and parallel glide dislocations play a governing role

* Results based on MD modeling, experiments, continuum theory and mesoscopic modeling (joint experiment-theory-simulation effort with Prof. Arzt group at MPI-MF)



Deformation map of submicron copper films

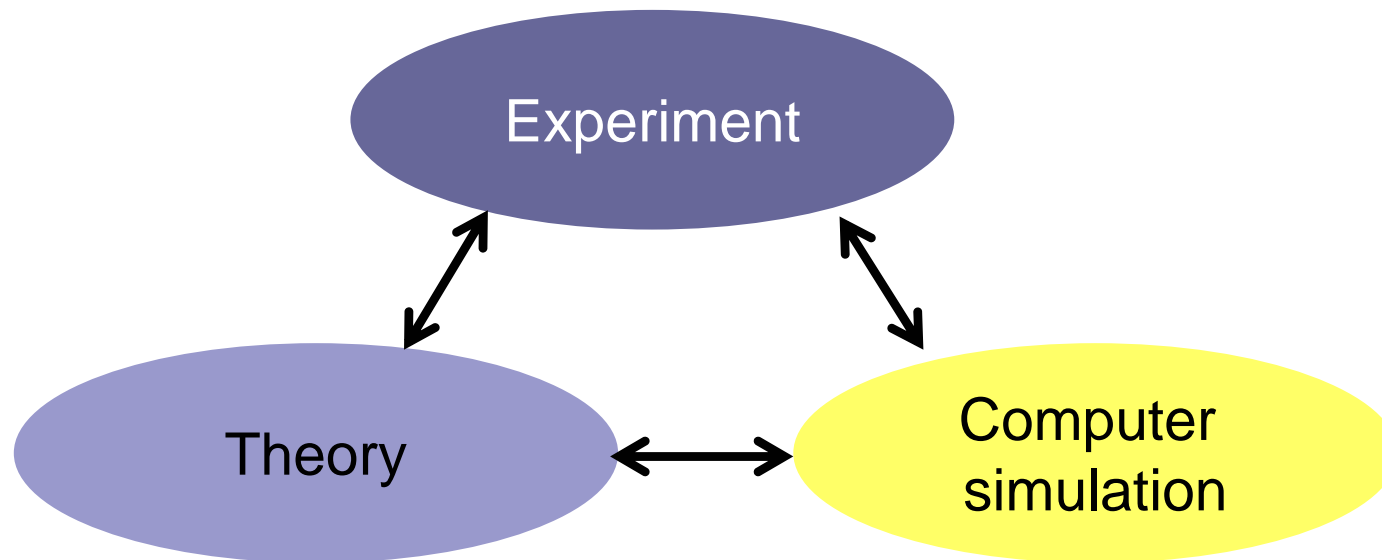




Experiment-theory-simulation



- Atomistic simulations is an increasingly important tool in materials science; it can be used to...
 - Advance theory and discover new physical phenomena
 - Augment and explain experiment
- With its **limitations** understood, MD simulation is an ideal tool to study small-scale dynamics materials phenomena; gain insight into mechanisms





Discussion and conclusion



- MD methods for metals are quite advanced and have found many applications
- This is true partly because the metallic bonding can reasonably well be described using semi-empirical potentials (EAM, MEAM); many models have been suggested in the past decades
- With increase in computing power this enables studies of billions of particles, allowing to reach the critical length scales of micrometers with “first principles” dislocation mechanics
- We have applied these techniques to gain insight into the deformation mechanisms of ultra thin copper films deposited on substrates
- We have discovered that diffusional processes play an increasingly important role at nanoscale and that the deformation mechanism of ultra thin copper films is characterized by parallel glide dislocations rather than threading dislocations



Lecture topics: Outline



Fall 2005

- Oct. 27, 1 PM, Room 1-134: Introduction to atomistic modeling techniques: Do we need atoms to describe how materials behave?
- Nov. 3, 1 PM, Room 1-134: Methods and techniques for modeling metals and their alloys and application to the mechanics of thin metal films
- Nov. 17, 1 PM, Room 1-134: Scale coupling techniques: From nano to macro
- Dec. 5, 1 PM, Room 1-150: Reactive versus nonreactive potentials: Towards unifying chemistry and mechanics in organic and inorganic systems

IAP 2006: From nano to macro: Introduction to atomistic modeling techniques and application in a case study of modeling fracture of copper (1.978 PDF)

- Jan. 9 (Monday): Introduction to classical molecular dynamics: Brittle versus ductile materials behavior
- Jan. 11 (Wednesday): Deformation of ductile materials like metals using billion-atom simulations with massively parallelized computing techniques
- Jan. 13 (Friday): Dynamic fracture of brittle materials: How nonlinear elasticity and geometric confinement governs crack dynamics
- Jan. 16 (Monday): Size effects in deformation of materials: Smaller is stronger
- Jan. 18 (Wednesday): Introduction to the problem set: Atomistic modeling of fracture of copper
- The IAP activity can be taken for credit. Both undergraduate and graduate level students are welcome to participate. Details will be posted on the IAP website (<http://web.mit.edu/iap/>).

Spring 2006

- TBD. Atomistic modeling of biological and natural materials: Mechanics of protein crystals and collagen
- TBD. Mechanical properties of carbon nanotubes: Scale effects and self-folding mechanisms
- TBD. Atomistic and multi-scale modeling in civil and environmental engineering: Current status and future development

<http://web.mit.edu/mbuehler/www/Teaching/LS/>